# *Colloquium*: The transport properties of graphene: An introduction

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An introduction to the transport properties of graphene combining experimental results and theoretical analysis is presented. In the theoretical description simple intuitive models are used to illustrate important points on the transport properties of graphene. The concept of chirality, stemming from the massless Dirac nature of the low-energy physics of the material, is shown to be instrumental in understanding its transport properties: the conductivity minimum, the electronic mobility, the effect of strain, the weak (anti)localization, and the optical conductivity.

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### **CONTENTS**

I. Introduction	2673
II. The Energy Spectrum of Graphene and the	
Emergence of Dirac Electrons	2674
III. Conductivity and Conductance of Graphene at the	
Dirac Point	2676
A. Sources of disorder	2676
B. Calculation of the conductivity minimum for bulk	
graphene due to disorder	2677
C. Calculation of the conductivity minimum for pristine	
graphene ribbons	2679
D. Puddles	2680
IV. The Transport Properties of Graphene at Finite	
Electronic Density	2681
A. The dependence of the conductivity on the gate	
voltage	2681
B. Partial-wave description of resonant scatterers	2684
C. Partial-wave description of Coulomb scatterers	2685
D. Transport across a strained region: A way of	
generating a transport gap	2687
V. Quantum Corrections to the Drude Conductivity	2689
A. Weak localization in a normal metal	2690
B. Weak localization in graphene	2691
VI. The Optical Conductivity of Graphene in the Infrared	
to Visible Range of the Spectrum	2692
A. Graphene as a transparent membrane	2692
B. The optical conductivity of neutral graphene	2694
C. The optical conductivity of gated graphene	2695
VII. Conclusions	2696
Acknowledgments	2696
References	2696

# **I. INTRODUCTION**

For a long time, theorists and experimentalists alike have considered the existence of a true two-dimensional (2D) material, having the thickness of a single atom—a one atom thick membrane-to be impossible. The reasoning behind this statement relies on the fact that both finite temperature and quantum fluctuations conspire to destroy the otherwise perfect 2D structure of the hypothetic material. These fluctuations, originated from

atomic vibrations perpendicular to the plane of the material, would preclude the existence of a true flat phase and concomitantly the existence of such a system.

Nevertheless, in 2004, a group led by A. K. Geim, from the University of Manchester, UK, isolated such a 2D material (Novoselov et al., 2004; Novoselov, Jiang, et al., 2005). Under the name of graphene, this new material is an allotropic form of carbon, with the atoms arranged in a 2D honeycomb lattice. The reason for the success lies on the isolation method. The developed method permitted one to isolate the 2D material on top of a 300-nm-thick wafer of silicon oxide. The weak van der Waals interaction induces adhesion between graphene and the wafer, and once on top of the wafer, it is possible to move about the 2D material, transferring it from one substrate to another or even having it suspended over a trench, supported from one side (Booth et al., 2008). In the production method, graphite plays a key role since this three-dimensional (3D) material is itself made of stacked graphene planes (binded by van der Waals forces). The ingenuity of the method was then to find a way of peeling a single layer of graphene out of graphite (Novoselov et al., 2004; Novoselov, Jiang, et al., 2005). Up to this date, the exfoliation of graphite can produce graphene crystallites as large as  $\sim 1 \text{ mm}^2$  (see Fig. 1). The study of graphene became, since 2004, an active field of research in condensed matter, which holds



FIG. 1. (Color online) An optical image of a graphene flake, obtained form the exfoliation of graphite, with an area of  $\leq 1 \text{ mm}^2$ , on top of a silicon oxide wafer (courtesy of P. Blake).

many promises (Castro Neto *et al.*, 2006; Geim and Mac-Donald, 2007; Geim and Novoselov, 2007; Katsnelson, 2007; Geim and Kim, 2008; Geim, 2009; Peres, 2009; Service, 2009; Castro Neto, 2010; Fuhrer *et al.*, 2010).

Being the first truly 2D material, it is natural to ask how its properties differ from those of more conventional systems, such as the 2D electron gas in the inversion layer of an ordinary semiconductor. The current efforts in graphene research have focused on the interplay among elastic, thermal, chemical, and electronic properties of the material, with a special emphasis on charge and heat transport, and on optical properties. The need for a deep understanding of the transport properties of graphene is obvious since the material is a potential candidate for incorporating the future generation of nanoelectronic and nanophotonic devices (Blake et al., 2008; Xia et al., 2009; Lin et al., 2010; Mueller et al., 2010; Schwierz, 2010). Also in biophysics, graphene is finding new applications (Lu et al., 2010; Schneider et al., 2010; Wu et al., 2010). Additionally, and of no less importance, graphene provides a realm for the emergence of new and exciting physics.

In the field of electronic applications, faster electronics requires smaller devices, in particular because at the nanoscale it may be possible for the electrons to travel across some of the components of a device almost unimpeded. In a normal conductor, one of the sources of electrical resistance is scattering of electrons by impurities and defects (and at room temperature, also by phonons). A measure of the effect of impurities on the electronic transport is the mean free path  $\ell$  (the average distance traveled by an electron between two consecutive collisions), which in a material with high degree of purity and with small dimensions can be larger than the typical length of the system  $L_x$  leading, in these circumstances, to what is called ballistic transport (in this regime the current becomes spatially nonuniform). It just happens that in graphene  $\ell$  can be as large as 1  $\mu$ m (Novoselov *et* al., 2004; Bolotin, Sikes, Hone, et al., 2008), putting graphene into the ballistic regime since the typical size of graphene-based field effect transistors is  $L_x \sim 0.25$  $-0.5 \ \mu m$  (Du *et al.*, 2008).

The first ground breaking publications of the Manchesters group (Novoselov *et al.*, 2004; Novoselov, Jiang, *et al.*, 2005) not only made the method of isolating graphene immediately public but also established the major relevant problems in graphene transport: the ambipolar field effect (see Fig. 9), the independence of the electronic mobility upon the gate voltage, the large electronic mean free path, the conductivity minimum and the absence of Anderson localization (Bardarson *et al.*, 2007), the magnetoresistance, and the chiral quantum Hall effect (Novoselov, Geim, *et al.*, 2005; Zhang *et al.*, 2005). These topics still orient much of the research in graphene physics at present.

Since the publication of a comprehensive review on the theoretical properties of graphene (Castro Neto *et al.*, 2009), there has been additional relevant contributions to experimental and theoretical studies of its transport properties. In this Colloquium, we present an up-



FIG. 2. (Color online) Real-space lattice and Brillouin zone of graphene. Left: The hexagonal lattice of graphene, with the nearest neighbor  $\delta_i$  and the primitive  $a_i$  vectors depicted. The area of the primitive cell is  $A_c = 3\sqrt{3}a_0^2/2 \approx 5.1$  Å<sup>2</sup> and  $a_0 \approx 1.4$  Å. Right: The Brillouin zone of graphene, with the Dirac points **K** and **K'** indicated. Close to these points, the dispersion of graphene is conical and the density of states is proportional to the absolute value of the energy.

date on the experimental and theoretical developments in this fast growing subfield of graphene research, at a level appropriate to graduate students entering the field.

# II. THE ENERGY SPECTRUM OF GRAPHENE AND THE EMERGENCE OF DIRAC ELECTRONS

As stated, graphene is a 2D material made solely of carbon atoms, arranged in a hexagonal lattice such as that shown in Fig. 2. There are five vectors represented in Fig. 2: the three next-nearest neighbors vectors  $\delta_i$  (i = 1,2,3), and the primitive cell vectors  $a_1$  and  $a_2$ . We further note that the hexagonal lattice is made of two interpenetrating triangular Bravais lattices. Therefore, the effective model describing the low-energy physics of graphene has to keep track of the two atoms per unit cell, characteristic of the honeycomb lattice. Electrons in graphene can be described by a tight-binding Hamiltonian reading (spin index omitted)

$$H = -t \sum_{n, \delta_i} |A, \mathbf{R}_n\rangle \langle \mathbf{R}_n + \delta_i, B| + \text{H.c.}, \qquad (1)$$

where  $|A, R_n\rangle$  represents the Wannier state at the unit cell  $R_n$ , and the equivalent definition holds for  $|B, R_n$  $+\delta_i\rangle$ ; *t* is the hopping energy. This Hamiltonian describes the motion of electrons in the  $\pi$  orbitals of the material, made from the hybridization of the atomic  $2p_z$  orbitals, and includes both low-energy and high-energy electron states. The calculation of the electronic energy spectrum of graphene proceeds by introducing, in Eq. (1), the Fourier representation of the Wannier states in terms of the Bloch states of momentum k; the spectrum then reads (Wallace, 1949; Castro Neto *et al.*, 2009)

$$E(\mathbf{k}) = \pm t |1 + e^{i\mathbf{k} \cdot \mathbf{a}_1} + e^{i\mathbf{k} \cdot \mathbf{a}_2}|.$$
<sup>(2)</sup>

It is immediately obvious that the band structure of the  $\pi$  electrons is composed of two bands, one at negative energies (a hole band) and the other at positive ones (a particle band).

In the Brillouin zone there are two special, nonequivalent (i.e., not connected by a reciprocal lattice

vector), wave numbers, termed K and K', and shown in Fig. 2. The transport properties of graphene are mostly determined by the nature of the spectrum around these two points. Close to K and K', the dispersion [Eq. (2)] is conical and is given by  $E(\mathbf{k}) = \pm v_F \hbar k$ , with  $v_F$  $=3ta_0/(2\hbar)$ , where k is the momentum measured relatively to either K or K', depending on the position of the cone in the Brillouin zone. Using the widely accepted value of  $t \approx -2.7$  eV for the hopping (in reality the values of t vary in the literature, spanning the interval from -2.7 to -3.1 eV) we obtain  $v_F \lesssim 10^6$  m/s. The experimental studies are consistent in obtaining  $v_F \simeq 1.1$  $\times 10^6$  m/s (Novoselov, Geim, et al., 2005; Zhang et al., 2005, 2008; Jiang et al., 2007). A direct measurement of the Dirac spectrum in graphene has recently been obtained using angle-resolved photoemission spectroscopy (Sprinkle et al., 2009). Since each carbon atom (electronic configuration  $1s^22s^22p^2$ ) hybridizes with its three nearest neighbors according to the hybrid orbitals  $sp^2$ , there is one electron left in the  $p_z$  orbital. Therefore, the system is half filled, with the important consequence that the low-energy physics is controlled by the spectrum close to the K and K' points. Many of the new and exciting properties of graphene stem from this fact. The vicinities of these two points are also referred to as the two valleys of the electronic spectrum of graphene.

The spectrum  $E(\mathbf{k}) = \pm v_F \hbar k$  is formally equivalent to that obtained from solving the 2D massless Dirac equation. Indeed, it is easy to show (Semenoff, 1984; Castro Neto *et al.*, 2009) that close to the  $\mathbf{K}$  point the effective Hamiltonian for the electrons in graphene has the form

$$H_{\boldsymbol{K}} = v_F \boldsymbol{\sigma} \cdot \boldsymbol{p}, \tag{3}$$

whereas close to K', the Hamiltonian is obtained from Eq. (3) by making the transformation  $H_{K'} = -H_K$ . The operator  $\sigma$  is written in terms of the Pauli matrices as  $\boldsymbol{\sigma} = (\sigma_{\rm r}, \sigma_{\rm v})$  and **p** is the momentum operator. Computing the eigenvalues of the Hamiltonian (3), the conical spectrum indicated above is immediately obtained. We stress that  $\sigma$  does not represent real electronic spin; it is instead a formal way of taking into account the two carbon atoms per unit cell in graphene, as anticipated above. For this reason,  $\sigma$  is termed pseudospin. The density of states associated with the conical dispersion of electrons in graphene is computed by determining the number of states per unit cell in the Brillouin zone N(E)up to the momentum k. Taking into account contributions from states near K and K' points, we obtain  $N(E) = k^2 A_c / (2\pi)$ , from which the density of states  $\rho(E)$ per spin and per unit cell is given by  $\rho(E) \equiv dN(E)/dE$  $=2|E|/\pi\sqrt{3}t^2$ , and the primitive cell area  $A_c$  is defined in the caption of Fig. 2. The linear dependence of the density of states on energy is one of the fingerprints of massless Dirac electrons. For neutral graphene, the Fermi energy is zero. Therefore, the density of states vanishes in this case.

The electronic linear spectrum and the chiral nature of the electron's wave function (see below) make electronic behavior in graphene quite unique and are re-



FIG. 3. (Color online) At the K valley, electrons have positive helicity, h=1, whereas at the K' one, the helicity is negative  $(Q = K' - K \text{ represents the transferred momentum when a scat$ tering event between the valleys takes place). In a head-on collision of the electron on a potential barrier, the backscattered electron has to change its momentum from q to -q. For such a head-on collision (taken here along the x direction),  $\hat{h}$  is a constant of motion, with eigenvalue +1, but backscattering would imply a modification of this eigenvalue to -1. This, however, cannot be because h is a conserved quantity, then the transmission probability through the barrier, for such type of collision, has to be one. Thus, backscattering is suppressed for intravalley scattering events. On the other hand, electrons in the K' and K valleys have opposite chirality, thus intervalley backscattering can take place (if the potential is short range) since in this case the eigenvalue of  $\hat{h}$  does not change sign. This discussion will be of importance for Sec. V.B.

sponsible for the remarkable properties of this material. Since  $\boldsymbol{\sigma} \cdot \boldsymbol{p} |\psi\rangle = \pm p |\psi\rangle$ , then the operator  $\hat{h} = \boldsymbol{\sigma} \cdot \boldsymbol{p} / p$  has only two eigenvalues  $\pm 1$ . The operator  $\hat{h}$  is known as the helicity operator and has the following physical interpretation: in an energy eigenstate, the pseudospin  $\sigma$  is either parallel or antiparallel to the momentum p. In the **K** valley, electrons have positive helicity and holes have negative helicity; in K' the opposite happens. The helicity (or chirality) of electrons in graphene is responsible for the Klein tunneling effect (Cheianov and Fal'ko, 2006; Katsnelson et al., 2006; Beenakker, 2008), observed recently in graphene heterojunctions (Stander et al., 2009; Young and Kim, 2009). We then see (and at odds to high-energy neutrino physics) that massless Dirac electrons in graphene come with both right and left chirality: parity is a symmetry of graphene. In Fig. 3 we show, in simple terms, the origin of the Klein tunneling effect: the probability of electronic transmission through a potential barrier is equal to 1 for head-on collisions; it is said that backscattering is suppressed.

We should note that chirality is not, however, an exact symmetry of the problem. This occurs because the spectrum of graphene is not exactly linear at all energies. The deviation from the perfect massless Dirac behavior is known as trigonal warping (McCann *et al.*, 2006; Narozhny, 2007) and starts playing a role for energies  $E \ge 1$  eV. We remark, however, that trigonal warping might be important for observation of weak localization at energies much lower than 1 eV (see Sec. V.B).

The solution of the eigenproblem  $H_K |\psi\rangle = E |\psi\rangle$  is easily obtained by recognizing its formal equivalence to that of a real spin in a magnetic field (Castro Neto *et al.*, 2009), with the wave function reading

$$|\psi_{\pm}\rangle = \frac{1}{\sqrt{2}} \begin{pmatrix} e^{-i\theta(\mathbf{k})/2} \\ \pm e^{i\theta(\mathbf{k})/2} \end{pmatrix} e^{i\mathbf{k}\cdot\mathbf{r}} \equiv u_{\pm}(\mathbf{k})e^{i\mathbf{k}\cdot\mathbf{r}}$$
(4)

and  $\theta(\mathbf{k}) = \arctan(k_y/k_x)$ . Since the eigenproblem we have just solved is formally identical to a spin one-half in a magnetic field, the spinors change sign upon the transformation  $\theta(\mathbf{k}) \rightarrow \theta(\mathbf{k}) + 2\pi$ , as dictated by the spin-statistics theorem.

The first striking consequence of the chiral nature of electrons in graphene was the observation of the chiral quantum Hall effect (Novoselov, Geim, *et al.*, 2005; Zhang *et al.*, 2005), where the Hall conductivity is quantized as  $\sigma_{xy}=2e^2(1+2n)/h$ , with n=1,2,... (Gusynin and Sharapov, 2005; Peres *et al.*, 2006). The quantization rule follows from the nature of the Landau levels of Dirac electrons (Rabi, 1928; Johnson and Lippmann, 1949; Nieto and Taylor, 1985; Peres and Castro, 2007) combined with the existence of the two valleys in graphene.

The application of the chiral quantum Hall effect to metrology, in defining the resistance standard (Delahaye and Jeckelmann, 2003), has clear advantages over the usual quantum Hall effect in the 2D electron gas since the same experimental accuracy on the quantization of the Hall resistance can be achieved at higher temperatures (Giesbers et al., 2008; Poirier and Schopfe, 2010; Tzalenchuk et al., 2010). At a temperature of 300 mK, the accuracy of the quantum Hall resistance quantization has been shown to be of 3 parts per billion, in monolayer epitaxial graphene (Poirier and Schopfe, 2010; Tzalenchuk et al., 2010). Also, the quantum Hall effect in graphene has been observed at room temperature (Novoselov et al., 2007) and recently in epitaxial graphene as well (Wu et al., 2009), which can be produced in quasifree standing form (Riedl et al., 2009).

Electron-electron interactions play no role in the halfinteger or chiral quantum Hall effect. On the other hand, they are a crucial ingredient in the explanation of the fractional quantum Hall effect. During the first few years of graphene research, effects of electron-electron interactions have been elusive, but the recent observation of the 1/3 fractional Hall plateau (Bolotin *et al.*, 2009; Du *et al.*, 2009; Morpurgo, 2009) brings them to forefront of this active research area. It is a remarkable experimental fact that the fractional quantum Hall effect in graphene can be observed at magnetic fields of 2 T and persists up to a temperature of 20 K for fields of 12 T.

Using the results introduced above, we proceed to the discussion of several topics on electronic transport in graphene.

# III. CONDUCTIVITY AND CONDUCTANCE OF GRAPHENE AT THE DIRAC POINT

As discussed in Sec. II, undoped graphene has its Fermi energy at the Dirac point, where the material has a vanishing density of states. This would naively suggest that the conductivity of undoped graphene should be zero. However, experiments challenge one's intuition and show a finite conductivity at zero energy (i.e., at the

### A. Sources of disorder

As in any other metallic system, the electronic mobility in graphene is hindered by disorder. The sources of disorder in graphene can vary, and can be due to adsorbed atoms (for example, hydrogen) or molecules (for example, hydrocarbons), extended defects, such as folded regions (wrinkles), vacancies, and topological defects [such as of Stone-Wales type, specially at the edges (Huang et al., 2009)]. Interestingly enough, in some particular cases, an extended defect in graphene can act as a 1D conducting channel (Lahiri et al., 2010). In addition, the system has a certain amount of rippling (random strain) (Meyer et al., 2007; Katsnelson and Geim, 2008), so it is not a perfect planar lattice, and it has rough edges, which can exhibit scrolling (Fogler *et al.*, 2010). We should note that, although the formation of vacancies is energetically unfavorable, the existence of adatoms and adsorbed hydrocarbons is likely, originating from the isolation method and exposure to the environment. Such adsorbed atoms can be imaged by transmission electron microscopy (Meyer et al., 2008). Additionally, the electrostatic random potential at the surface of the silicon-oxide substrate acts as an additional scattering source, originated from charged impurities (Zhang et al., 2009).

To a good practical approximation, an adsorbed hydrocarbon, when binding covalently to the  $2p_z$  orbital of a given carbon atom of graphene, effectively removes the  $2p_z$  electron from participating in the electric transport, by forming a  $\sigma$  bond. Since the electron wave function is spatially confined, the impurity can effectively act as a vacancy. This latter type of defects induce resonant states at, or close to, the Dirac point (see below).

Another way of looking at this problem is to consider that, say, an hydrogen atom when binding covalently (Katoch *et al.*, 2010) to a carbon atom in graphene changes locally the hybridization from pure  $sp_2$  to partially  $sp_3$  and creates, as before, a resonant impurity at that site (Robinson *et al.*, 2008; Castro Neto and Guinea, 2009). In this latter sense, both local potentials and adatoms have a similar effect (Stauber, Peres, and Castro Neto, 2008). The change of the chemical bonds from pure  $sp_2$  to partially  $sp_3$  adds an additional scattering effect originated from the enhancement of spin-orbit coupling (Castro Neto and Guinea, 2009).

Combined with charged scatterers, the resonant scattering mechanism is currently ascending as one of the dominant processes limiting the electronic mobility in graphene (Ni *et al.*, 2010).

The resonant scattering mechanism is easy to understand by considering a simple model. We add to the Hamiltonian (1) a contribution from an impurity binding covalently to a carbon atom at site  $R_n = 0$ . Such a situation adds to the Hamiltonian a term of the form  $H_{\rm rs}$ = $(V|ad\rangle\langle A, 0|$ +H.c.)+ $\epsilon_{ad}|ad\rangle\langle ad|$ , where V is the hybridization between the adatom (or a carbon atom of a hydrocarbon molecule) and a given carbon atom of graphene,  $\epsilon_{ad}$  is the relative (to graphene's carbon atoms) on-site energy of the electron in the adatom, and  $|ad\rangle$  is the ket representing the state of the electron in the adatom. Taking the wave function to be of the  $|\psi\rangle = \sum_{n} [A(\mathbf{R}_{n})|A,\mathbf{R}_{n}\rangle + B(\mathbf{R}_{n}+\delta_{2})|B,\mathbf{R}_{n}+\delta_{2}\rangle]$ form  $+C_{ad}|ad\rangle$ , the Schrödinger equation at the site  $R_n=0$ reads

$$EA(0) - VC_{ad} = -t[B(\boldsymbol{\delta}_1) + B(\boldsymbol{\delta}_2) + B(\boldsymbol{\delta}_3)], \quad (5)$$

$$(E - \epsilon_{\rm ad})C_{\rm ad} = VA(0). \tag{6}$$

Solving for  $C_{ad}$ , we obtain

$$-t[B(\boldsymbol{\delta}_1) + B(\boldsymbol{\delta}_2) + B(\boldsymbol{\delta}_3)] = EA(0) - \frac{V^2 A(0)}{E - \epsilon_{\rm ad}}.$$
 (7)

The resonant effect is included in the last term of Eq. (7), which represents a local potential of the form  $V_{\rm eff}$  $=V^2/(E-\epsilon_{\rm ad})$ . Equation (7) contains two interesting regimes: (i) when  $|E| \ll \epsilon_{ad}$ , the adatom acts as an effective local potential of strength  $g_{\rm eff} = V^2 / \epsilon_{\rm ad}$ . If  $g_{\rm eff}$  is large, the adatom acts roughly as an effective vacancy; a vacancy is characterized by  $g_{\rm eff} = \infty$ ; (ii) when  $E \approx \epsilon_{\rm ad}$ , the hopping from the carbon atom at position  $R_n=0$  to its nearest neighbors is suppressed [effectively we have  $t \rightarrow (E$  $-\epsilon_{ad}t]$ , and the adatom acts roughly and again as an effective vacancy at energies close to  $\epsilon_{ad}$ . Therefore, either by inducing an effective local potential or by suppressing the nearby hopping we see that such mechanism increases the likelihood of an electron being trapped for a longer time in the vicinity of the adatom, thus generating a resonant state.

If  $\epsilon_{ad} \approx 0$ , then the resonant states will be exactly at the Dirac point, and this is expected to happen for adsorbed hydrocarbon molecules. It is then the job of quantum chemical calculations to determine the value of the parameters  $\epsilon_{ad}$  and V (Robinson *et al.*, 2008; Wehling et al., 2009, 2010). Recently obtained typical values are  $V \sim 2t \sim 5$  eV and  $\epsilon_{ad} \sim -0.2$  (Wehling *et al.*, 2010), leading to  $g_{\rm eff} \sim 100$  eV, a rather strong on-site potential. Finally, calculation of the transport properties for such a model can be performed using the T-matrix approach (Peres, Klironomos, et al., 2007; Robinson et al., 2008; Peres, Yang, and Tsai, 2009). Its derivation is elementary, using the simple model described above. It is well known that the T matrix for a local potential of intensity  $v_0$  reads (Bena and Kivelson, 2005; Peres *et al.*, 2006)  $T(E) = v_0 [1 - v_0 \overline{G}_R(E)]^{-1}$ . Then, for an adatom we must have



FIG. 4. (Color online) Numerically exact density of states (solid lines), in the limit  $v_0 \rightarrow \infty$ , and the corresponding SCBA calculation (dashed lines), for the same impurity concentrations  $n_i$ . The maximum of the SCBA density of states, at E=0, follows the rule  $\rho(E) \approx 0.2\sqrt{n_i} \text{ eV}^{-1}$ . Inset: The function K(0) is plotted for a range of impurity concentrations spanning three orders of magnitude. (The numerically exact calculations are courtesy of Vitor M. Pereira.)

$$T(E) = \frac{V_{\text{eff}}}{1 - V_{\text{eff}}\bar{G}_R(E)} = \frac{V^2}{E - \epsilon_{\text{ad}} - V^2\bar{G}_R(E)}.$$
(8)

Using Eq. (8), it is simple to compute the transport relaxation time  $\tau(\epsilon_F)$  at the Fermi energy  $\epsilon_F$  using  $\hbar/\tau(\epsilon_F) = \pi n_i |T(\epsilon_F)|^2 \rho(\epsilon_F)$ , where  $n_i$  is the concentration of impurities per unit cell. From the knowledge of  $\tau(\epsilon_F)$ , the conductivity of graphene follows from Boltzmann's transport equation (Ziman, 1979) (see Sec. VI.C). The function  $\bar{G}_R(E)$  reads  $\bar{G}_R(E) = ED^{-2} \ln(E^2/D^2)$  $-i\pi |E|/D^2$ , with  $D \approx 3t$ .

It has been theoretically predicted that, in addition to their scattering effect, monovalent adatoms in diluted concentrations can create a gap in graphene's spectrum, by a mechanism called *sublattice ordering* (Cheianov *et al.*, 2010). Superlattices of vacancies (or adatoms) have the same effect (Martinazzo *et al.*, 2010).

Midgap states (Jackiw, 1984) are also produced by a model of pure vacancies (Pereira *et al.*, 2006, 2008), as shown in Fig. 4, and if a nearest-neighbor hopping  $(t' \approx 0.4 \text{ eV})$  is included, the resonant states, while no longer at exactly the Dirac point, remain at energies close to it (Pereira *et al.*, 2006, 2008).

# B. Calculation of the conductivity minimum for bulk graphene due to disorder

It is certainly difficult to model all the different types of disorder just mentioned in a single calculation. We for the moment ignore this complexity and assume that electrons in graphene move in a random potential of the form  $V(\mathbf{r}) = v_0 \sum_{n=1}^{N_i} \delta(\mathbf{R}_n - \mathbf{r})$ , where the position vectors  $\mathbf{R}_n$  are random,  $v_0$  is the strength of the potential, and  $N_i$ is the number of scattering centers. This model can be seen in the worst case scenario as zero-order description of the effect of impurities in graphene, although it has recently been used widely (Ando and Nakanishi, 1998; Suzuura and Ando, 2002; Zheng and Ando, 2002; Ostrovsky *et al.*, 2006, 2007; Peres *et al.*, 2006). In fact, for large  $v_0$  this model mimics the resonant scatterers physics. In what follows, we determine the consequences of the above random potential on the minimum conductivity of graphene.

The usual approach to the calculation of the conductivity uses the Kubo-Greenwood formula, obtained from linear response theory (Mahan, 2000). The calculation proceeds in two steps (Shon and Ando, 1998; Zheng and Ando, 2002; Peres *et al.*, 2006): first, the single particle Green's function in the presence of the disordered potential is computed in a self-consistent manner; second, the current-current correlation function is obtained in terms of the single particle Green's function. This method is known as the self-consistent Born approximation (SCBA). The final result of such calculation is a simple expression for the conductivity  $\sigma(\epsilon_F)$  at the Fermi energy reading

$$\sigma(\epsilon_F) = \frac{4e^2}{\pi h} K(\epsilon_F), \qquad (9)$$

where  $K(\epsilon_F)$  is a dimensionless function (Peres *et al.*, 2006; Stauber, Peres, and Castro Neto, 2008); Eq. (9) holds true both at finite  $v_0$  or when  $v_0 \rightarrow \infty$ ; from here on we consider this latter regime only. Since we describe the transport at the Dirac point, we need the value of  $K(\epsilon_F)$  at zero chemical potential, which turns out to be  $K(0) \approx 1$ . This result is essentially insensitive to the concentration of impurities  $n_i = N_i A_c / A$  (A is the area of the sample and  $n_i$  is the concentration of  $n_i$  is shown in the inset of Fig. 4; as stated, its value is 1.

We have, therefore, obtained a universal value for the conductivity minimum of graphene  $\sigma_{\min}=4e^{2}/\pi h$  independent of the impurity concentration, even if the concentration of impurities is a small number. Many have reached the same result using different approaches (Ziegler, 2007; Dóra *et al.*, 2008). A question naturally arises: How does one understand the result given by Eq. (9)? To that end, we compute the density of states of disordered graphene.

We have compared a calculation of the density of states as given by the SCBA with that given by an exact numerical method (Pereira et al., 2006, 2008). In Fig. 4 we show two sets of calculations for the density of states close to the Dirac point  $(E \sim 0)$ . Two features are clear from these calculations. First, the disorder only affects the density of states (DOS) close to the Dirac point, rendering it finite; second the SCBA introduces a smoothing of DOS around  $E \sim 0$ , but its value essentially agrees with the exact one, except at energies very close to E=0. The finite density of states close to the Dirac point is due to the wings of the resonant states forming at zero energy. The same behavior is seen in the local density of states around a single vacancy and in the corresponding scanning tunneling microscopy current (Peres, Klironomos, et al., 2007; Peres, Yang, and Tsai, 2009).



FIG. 5. (Color online) The conductivity of graphene at the neutrality point. Left: Conductivity minimum from the Manchesters group [data from Geim and Novoselov (2007)]. Right: Conductivity minimum from the Columbias group [data from Tan *et al.* (2007)] as a function of the mobility of the devices. In both panels, several devices with different mobilities  $\mu$  were measured. The mobility is defined as  $\mu = \sigma(\epsilon_F)/en$ , where *n* is the electron density, and is a measure of the amount of disorder in the system. The constant  $g_0$  stands for twice the quantum of conductance,  $2e^2/h \approx 0.078 (k\Omega)^{-1}$ , and is represented by the dashed line. The dash-dotted line represents the value  $\sigma = \sigma_{\min}$ , obtained in Sec. III.B.

The above comparison shows that the SCBA gives a reasonable description of the density of states close to the Dirac point, and this gives us a certain amount of confidence in the calculation of the conductivity  $\sigma(\epsilon_F)$  based on the same approximation. A comment on the behavior of the numerical DOS close to zero energy is in order: the sharp feature at precisely E=0 seen in the exact numerical solution arises from the presence of zero-energy quasilocalized modes, induced by the vacancies in the lattice (Pereira *et al.*, 2006, 2008). These localized states are clearly not captured by the SCBA.

In short, the finiteness of the conductivity at the Dirac point is a consequence of the finiteness of the DOS at  $E \sim 0$  due to disorder, even when the concentration of impurities is small, since K(0) is essentially constant over several orders of magnitude of impurity concentration. Furthermore, there is a strong criticism in the literature regarding the application of the SCBA approach to describe the physics at  $\epsilon_F \approx 0$  (Aleiner and Efetov, 2006), but not at finite  $\epsilon_F$ , as long as weak localization effects are not important (see Sec. V.A).

If one considers that the scattering centers are charged impurities, the conductivity of graphene, at the neutrality point, acquires the form (Fogler, 2009)  $\sigma_{\min} = (e^2/h)c\mathcal{L}$  with  $c=0.5\pm0.05$  and  $\mathcal{L}$  the solution of the transcendent equation  $\mathcal{L}=\ln[1/(4\mathcal{L}/\alpha_g^{\text{eff}})]$ , where  $\alpha_g^{\text{eff}}$  is the effective fine structure constant of graphene (see Sec. IV.C). This result for the conductivity minimum is different from that obtained for short-range scatterers.

Finally, the measured conductivity minimum, as shown in Fig. 5, has the same order of magnitude as that

given by  $\sigma_{\min}$  but is larger than this value and has a finite variance. It is important to note that the assessment of the transport properties of graphene at the neutrality (or Dirac) point can be strongly affected by the used probe geometry, the use of invasive contacts, or the lack of effective control on the sample's homogeneity (Blake *et al.*, 2009; Connolly *et al.*, 2010). These effects are responsible for the differences in the two sets of measurements given in Fig. 5.

# C. Calculation of the conductivity minimum for pristine graphene ribbons

Graphene ribbons have been produced by different methods: etching of exfoliated graphene (Han *et al.*, 2007), using chemical reactions (Li, Wang, *et al.*, 2008; Jiao *et al.*, 2010), unzipping carbon nanotubes (Kosynkin *et al.*, 2009), and tailoring them by scanning tunneling microscope lithography (Tapasztó *et al.*, 2008). Much of the experimental challenge regarding the production of nanoribbons is related to the discovery of an experimental procedure allowing, in a systematic way, the engineering of ribbons with fixed widths and perfect edges, together with a detailed characterization of their transport properties (Han *et al.*, 2010).

The previous section addressed the problem of the conductivity minimum of graphene from the point of view of disorder. Another relevant problem is that of the transport properties of pristine ribbons, where electrons can be in the ballistic regime. The problem we are about to discuss is a rather interesting one, since electronic transport will proceed via evanescent modes, whereas in normal metals charge transport is associated with propagating states.

We show below, and also in this case, the system has a finite conductivity, which in some conditions has the same value we found in Sec. III.B although the physical mechanism is different. The approach to the calculation of the conductivity of ribbons in the balist regime uses Landauer's formalism (Nazarov and Blanter, 2009), where the relevant quantity to be computed is the conductance of the system, which can formally take into account quantum interference effects, absent from the elementary Boltzmann's transport theory (see Sec. V.A).

The measurements in bulk metals of dc-transport properties allow one to obtain directly the resistance Rof the sample, from which the linear conductance G=1/R can be determined. In bulk metals, we can define a material intrinsic quantity, the conductivity  $\sigma$ . Taking the example of a 2D system, we have  $\sigma = GL_x/L_y$ , where  $L_x$  and  $L_y$  are the longitudinal and transverse dimensions of the bulk sample, respectively. The conductivity is a well-defined quantity whenever the system is large enough, such that the electronic current is homogeneous and insensitive to variations of the impurities' position from sample to sample. In this regime the transport is well described by Boltzmann's transport equation. The validity of this equation assumes that (Ferry *et al.*, 2009) (i) the scattering process is local in space and time, (ii) the scattering is weak and the electric field is small, and (iii) the de Broglie wavelength of the electron at the Fermi surface is much smaller than the distance between impurities. The systems amenable to such description are said to be *self-averaging*. (In 2D, both  $\sigma$  and G have the same units,  $1/\Omega$ .)

When the system's size is reduced, we enter the realm of mesoscopic physics. It is instructive to compute the order of magnitude of the number of impurities in a graphene flake with an area of  $A = L^2$  and  $L = 0.25 \ \mu m$ (see Sec. I). Taking  $N_i/A = 5 \times 10^{11}$  cm<sup>-2</sup> as a typical impurities' concentration in graphene (see Sec. IV.B for understanding the origin of this number), we obtain  $N_i$  $\sim 3 \times 10^2$  impurities. The typical distance between impurities is  $d \sim \sqrt{A/N_i} \sim 0.02 \ \mu$ m; a typical Fermi wave number for the electrons is graphene is  $k_F \sim 0.003 \ \mu \text{m}^{-1}$  (see Sec. IV), from which follows that de Broglie wavelength of the electrons at the Fermi surface is  $\lambda_F = 2\pi/k_F$  $\sim 0.02 \ \mu m$ , making d and  $\lambda_F$  of the same order of magnitude. In this regime, the current becomes nonhomogeneous and sensitive to the position of the impurities in the material. Then, the conductance shows fluctuations from sample to sample, and the concept of conductivity loses its meaning. Metallic systems such as graphene are considered highly conducting but disordered metals. The behavior of the electrons becomes sensitive to the metal contacts, surfaces, and interfaces as well and quantummechanical interference effects become important. Due to these interference effects, the transport properties of mesoscopic systems in the ballistic regime are better assessed by the Landauer's formalism (Ferry et al., 2009).

In calculating the conductance of pristine graphene ribbons, we assume a ribbon of length  $L_x$  and width  $L_y$ , connected to heavily doped (say, with electrons) graphene leads (see Fig. 10 for the geometry of the device). The doped graphene leads will act as electron reservoirs, and the doping is modeled by gating the leads at a potential  $V_g$ .

Since the leads are gated, there is a mismatch between the longitudinal momentum  $k_x$  of the electrons in the leads and in the central part of the device, where the undoped graphene ribbon lies; in the device electrons have longitudinal momentum  $q_x$ . The momentum  $k_y$  is in this case a conserved quantity. The problem is then that of computing the transmission amplitude for an electron coming from the left lead to emerge at the right one. The energy of the electrons at the right and left leads is given by  $E = -eV_g \pm v_F \sqrt{k_x^2 + k_y^2}$ ; in the central region the energy is given by  $E = \pm v_F \sqrt{q_x^2 + k_y^2}$ . We further impose periodic boundary conditions along the transverse direction, which gives  $k_v = 2\pi n/L_v$  with n  $=0,\pm 1,\pm 2,\ldots$ . Since we are interested in graphene's transport properties at the Dirac point, we have to consider the case of zero energy. For this energy, the solution of  $\sqrt{q_x^2 + k_y^2} = 0$  gives  $q_x = ik_y$  and therefore the propagation of the electrons in the central region proceeds by means of evanescent waves.

The scattering problem requires writing the wave function on the left and right leads and on the central region (Katsnelson, 2006; Tworzydlo *et al.*, 2006). In the left lead, the wave function, up to a multiplicative factor of  $e^{iyk_y}$ , reads

$$\psi_L(\mathbf{r}) = \begin{pmatrix} 1\\ e^{i\theta(\mathbf{k})} \end{pmatrix} e^{ik_x x} + r_n \begin{pmatrix} 1\\ -e^{-i\theta(\mathbf{k})} \end{pmatrix} e^{-ik_x x}.$$
 (10)

In the central region the wave function can be written as

$$\psi_C(\mathbf{r}) = a_n \binom{0}{1} e^{-k_y x} + b_n \binom{1}{0} e^{k_y x}.$$
(11)

Finally, in the right lead we have

$$\psi_R(\mathbf{r}) = t_n \begin{pmatrix} 1\\ e^{i\theta(\mathbf{k})} \end{pmatrix} e^{ik_x x}.$$
 (12)

The calculation of the transmission amounts to imposing the continuity of the wave function at x=0 and  $x=L_x$ and determining the transmission amplitude  $t_n$  from which the transmission associated to a given transverse mode *n* is obtained as  $T_n = |t_n|^2$  (to each quantized  $k_v$ momentum corresponds a *n* transverse mode). The final result for the total transmission at zero energy is (Katsnelson, 2006; Tworzydlo *et al.*, 2006)  $T = \sum_n T_n$  $\simeq \sum_{n} 1/\cosh^2(k_v L_x)$ . As stated, the conductance G is expressed in terms of the conductivity  $\sigma$  as  $G=4e^2T/h$  $=\sigma L_v/L_x$ . In the regime  $L_v/L_x \ge 1$ , corresponding to ballistic transport, we have  $T \simeq L_v/L_x \pi$ , and therefore  $\sigma = \sigma_{\min}$ , the same value obtained in Eq. (9), due to disorder. We stress that, for graphene ribbons, only in the regime  $L_v/L_x \ge 1$  is the conductivity a well-defined quantity since only in this case is this quantity independent of the aspect ratio of the ribbon.

The extension of this type of calculations to finite temperatures is elementary, and it follows from the Laudauer's formalism as well. Such theoretical investigations were done and the results seem to be in qualitative agreement with transport measurements made in highmobility suspended graphene (Müller *et al.*, 2009).

The conductance of ribbons, with aspect ratio  $L_y/L_x \ge 1$ , was experimentally measured, and the value  $\sigma = \sigma_{\min}$  was obtained (Miao *et al.*, 2007; Danneau *et al.*, 2008) in agreement with the previous result. There are, however, difficulties associated with measuring the conductivity of graphene ribbons at the neutrality point (Blake *et al.*, 2009) since inhomogeneous samples tend to overvalue the minimum of conductivity and two-probe measurements are generally expected to undervalue it (Blake *et al.*, 2009). Due to these subtleties, there is some reserve in the community (Blake *et al.*, 2009) regarding the measured conductances (Miao *et al.*, 2007; Danneau *et al.*, 2008).

We note that the above result for  $\sigma_{\min}$ , being equal to that computed in Sec. III.B, has a different physical origin. The result obtained here is only valid in the regime  $L_y/L_x \ge 1$  when the system is in the ballistic regime. However, one must recognize that the presence of the evanescent modes in the above calculation produces a finite density of states at the Dirac point, precisely what happens in the bulk disordered graphene calculation discussed in Sec. III.B. When the calculation just described



FIG. 6. (Color online) Dependence of the absolute value of electron density on the gate voltage  $V_g$ . In Sec. IV, we show that the electron density n as a function of the gate voltage follows  $n=7.2 \times 10^{10} V_g$  cm<sup>-2</sup>. Using this, the electron density for  $V_g=3$  V should be  $n \approx 2.2 \times 10^{11}$  cm<sup>-2</sup>, whereas for  $V_g=2$  eV we should have  $n \approx 1.4 \times 10^{11}$  cm<sup>-2</sup>. It is clear that for  $V_g=3$  the electronic density is the predicted one; however, n never equals its predicted value for  $V_g \approx 2$  V. Note that the vertical scale is logarithmic. [Data from Monteverde *et al.* (2010), courtesy of Monteverde.]

for graphene in ballistic regime  $(L_y \ge L_x)$  includes the effect of resonant scatterers, the conductance is corrected by the value  $\delta G = 4\sigma_{\min}/\pi$  per resonant scatterer (Titov *et al.*, 2010), that is, we have impurity-assisted tunneling (Titov, 2007).

As a last comment, we note that the important topics of edge disorder (Lewenkopf *et al.*, 2008; Mucciolo *et al.*, 2009; Gallagher *et al.*, 2010) and Coulomb blockade in graphene nanoribbons are not considered in this Colloquium since they have been considered elsewhere (Dubois *et al.*, 2009). A review on the effect of disorder on the electronic transport in graphene nanoribbons is also available (Mucciolo and Lewenkopf, 2010).

#### **D. Puddles**

We now address the fact that the model developed in Sec. III.C for the conductivity of graphene at the Dirac point is somewhat simplistic since it assumes the possibility to have graphene with exactly zero electronic density at E=0, the neutrality point.

The physics close to the Dirac point is different from that at finite densities (to be discussed in Sec. IV) as suggested by the data shown in Fig. 6. In Sec. IV we show that the electronic density *n* can in graphene on top of silicon oxide be externally controlled by a gate potential  $V_g$  and given by  $n \approx 7.2 \times 10^{10} \times V_g \text{ cm}^{-2}$ . According to this equation, the electron density can be tuned all the way down to zero by changing the gate potential. However, in Fig. 6 we show that the absolute value of the electron density never drops below its theoretically predicted value for  $V_g=2$  V. This experimental fact hints for different physics close to the Dirac point, where the system shows important charge-density fluctuations caused by the random electrostatic potential

2681

due to subsurface charged impurities. We, however, stress that in suspended annealed graphene the electronic density can be made as low as  $\sim 10^8$  cm<sup>-2</sup>, which corresponds to about a single electron present in a micron size device. Additionally, graphene's topography shows corrugations, which are probably due to roughness in the underlying SiO<sub>2</sub> surface and due to intrinsic ripples of the graphene sheet.

As mentioned, the calculations in Secs. III.B and III.C assume as the starting point that graphene is a perfectly flat material, with null electronic density everywhere. However, experiments using a scanning single-electron transistor (Martin et al., 2008) found that the idealized models of Secs. III.B and III.C do not hold. Those investigations (Martin et al., 2008) found undoped graphene to be a nonhomogeneous system, with electron and hole puddles coexisting, with variations in the electronic density in the range  $n \in [-1,1] \times 10^{11} \text{ cm}^{-2}$ , which corresponds to a spatial variation of the surface electrostatic-potential in the range [-0.25, 0.25] V, with a full width at half maximum of 50 mV. The behavior shown in Fig. 6 is an indirect signature of this experimental fact. The existence of puddles renders the descriptions of Secs. III.B and III.C unsuitable.

Posteriorly, a scanning tunneling microscopy (STM) study (Zhang *et al.*, 2009) was able to provide detailed information on the size and electronic density value of the puddles. This study allowed one to characterize the puddles with electron-density spatial resolution two orders of magnitude higher than previous investigations (Martin *et al.*, 2008). From the results of Sec. II, we can write a relation between the electronic density and the energy as  $n = E^2/\pi v_F^2 \hbar^2$ . Given the presence of the puddles, the energy becomes a function of position, as does the electronic density. We thus have a relation between the electronic density and the energy, reading

$$n(x,y) = E_D^2(x,y)/\pi v_F^2 \hbar^2.$$
 (13)

The STM allows the determination of  $E_D^2(x,y)$ , from which n(x,y) is obtained. These studies revealed that the average lateral dimension of the puddles is of the order of ~20 nm [a theoretical study (Rossi and Das Sarma, 2008) obtained a similar value and that each of these puddles contains, on average, a charge of  $0.3 \pm 0.2$  electron. A Kohn-Sham theory of the carrier-density distribution of massless Dirac fermions in the presence of arbitrary external potentials has also predicted the existence of the puddles (Polini et al., 2008). It was experimentally determined that the topographical corrugations in graphene are about an order of magnitude smaller than the puddles' size, and therefore cannot justify their origin. Indeed, it was established that individual subsurface charged impurities are responsible for the formation of the puddles and it was estimated that the charge fluctuations associated with a single of those impurities is of the order of  $0.07 \pm 0.03$  electron. There is, therefore, a consensus that the physics of the puddles is due to charged scatterers. The origin of such charged scatterers is likely to be due to chemical species physisorbed onto graphene, which have been trapped in between the substrate and the graphene sheet during fabrication process of the device.

From a theoretical point of view, graphene in the puddles regime can be thought as a random resistor network (Cheianov et al., 2007). Since Klein tunneling (Beenakker, 2008) is exponentially suppressed if the barriers are not perfect potential steps (Cheianov and Fal'ko, 2006), a large electronic transmission will not occur, except for perfectly normal incidence [things are markedly different for magnetic barriers as opposed to electrostatic ones (De Martino et al., 2007)]; the essential physics relating the smoothness of potential barriers to the suppression of Klein tunneling was studied in the early days of relativistic quantum mechanics, following a suggestion by Bohr (Sauter, 1931; Christillin and d'Emilio, 2007). The validity of the random resistor model depends on the assumption that transport is incoherent at scales larger than the puddle sizes. Due to Klein tunneling, massless Dirac electrons cannot also localize (Anderson localization) (Cheianov and Fal'ko, 2006; Katsnelson et al., 2006; Lewenkopf et al., 2008; Mucciolo et al., 2009) under the effect of the random electrostatic potential (long-range scatterers) creating the puddles; this accounts for the finite conductivity of graphene at the Dirac point. As discussed in Sec. V.B, long-range scatterers preclude the possibility of weak localization effects, and since the electrostatic potential variations can be attributed to charged impurities, the description of transport at the Dirac point based on such type of scatterers seems to be the correct approach (Adam et al., 2007).

We note that intracone backscattering (see Sec. V.B) has been shown to be present in graphene (Zhang *et al.*, 2009), which in view of Klein tunneling is a rather interesting experimental fact. Finally, when strong intervalley scattering is present, electrons in graphene can localize.

# IV. THE TRANSPORT PROPERTIES OF GRAPHENE AT FINITE ELECTRONIC DENSITY

In the previous section we discussed STM experiments supporting the theory (Polini *et al.*, 2008; Rossi and Das Sarma, 2008) that charge scatterers dominate the electronic transport of neutral graphene. In the ensuing sections, we discuss transport in doped graphene, analyzing the role that resonant and charged scatterers play in this regime.

### A. The dependence of the conductivity on the gate voltage

We now discuss the dependence of the conductivity of graphene on the gate voltage, considering two different types of scatterers: resonant scatterers (strong short-range scatterers) and charged impurities. We shall not discuss here scattering from random strain (Katsnelson and Geim, 2008), which we defer to Sec. IV.D.

The electronic density in graphene can be controlled by the backgate of a device engineered as a plane



FIG. 7. (Color online) The conductivity of suspended and nonsuspended graphene as function of the gate voltage. Top panels: Conductivity of suspended graphene from two different devices, after current annealing ( $\ell \sim 1 \mu m$ ). The top left panel corresponds to a device with  $\mu \sim 170\,000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ , at electronic density of  $n=2\times 10^{11}$  cm<sup>-2</sup> (data from Bolotin, Sikes, Hone, et al. (2008), courtesy of Bolotin). The top right panel corresponds to a device with  $\mu \sim 200\,000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ , at electronic density of  $n=2\times 10^{11}$  cm<sup>-2</sup> [data from Bolotin, Sikes, Jiang, et al. (2008), courtesy of Bolotin]. Bottom panels: Conductivity of graphene on top of silicon oxide, corresponding to devices with  $\mu \sim 10000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$  [data from Tan *et al.* (2007), courtesy of Kim]. In all panels the fits use the model developed in Sec. IV.B, with  $n_i$  as the only fitting parameter; R has to be of the order of  $a_0$  (Wehling *et al.*, 2010). In the legends, the concentration of impurities is per unit cell.

capacitor—a field effect transistor, made of silicon oxide (relative permittivity  $\epsilon$ =3.9), with a thickness *b* of ~300 nm. According to elementary electrostatics, the electric field in the dielectric is given by  $E_{cap}=en/\epsilon_0\epsilon$ , with *n* the surface electronic density of graphene, which acts as one plate of the capacitor. The gate potential is related to the electric field by  $E_{cap}=V_g/b$ , and so the density of induced charge is  $n = \epsilon_0 \epsilon V_g/eb$ . Inserting the numerical values of  $\epsilon$  and *b*, we obtain  $n = \alpha V_g$ , with  $\alpha$  $\approx 7.2 \times 10^{10} \text{ V}^{-1} \text{ cm}^{-2}$ . The Fermi momentum  $k_F$  is obtained via  $k_F = \sqrt{\alpha \pi V_g}$ , a result derived by counting the states in momentum space up to  $k_F$ .

Ever since the original paper on graphene (Novoselov et al., 2004) demonstrating the ambipolar field effect, it became clear that the conductivity of graphene depends on the gate voltage in some circumstances roughly as  $\sigma(\epsilon_F) \propto V_g$ ; this is shown in Fig. 8, after some replotting of the data (solid curve on the right panel). Experiments also show conductivities presenting a sublinear behavior; see Figs. 7 (solid curve) and Fig. 8 (dashed curve on the right panel). Mobilities, a measure of the quality of the electronic transport (see caption of Fig. 5 for the definition of the mobility  $\mu$ ), as high as  $\mu \sim 1 \times 10^7 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ , have been indirectly measured by Landau level spectroscopy (Li and Andrei, 2007; Li et al., 2009) of graphene flakes on top of graphite (Neugebauer et al., 2009), raising the question of how perfect



FIG. 8. (Color online) Resistivity and conductivity of graphene on top of silicon oxide. Top left panel: Raw data of a measurement of the resistivity  $\rho_{\text{measured}}$  of an exfoliated graphene sheet [data from Morozov *et al.* (2008)]. Right panel: Fit of the conductivity using Eq. (20) for the case where  $\sigma_{\text{sub}}=1/\rho_{\text{measured}}-\rho_S$ , with  $\rho_S=100 \Omega$  [the value of  $\rho_S=100 \Omega$  is that used by Morozov *et al.* (2008)]. Bottom left panel: Data  $\sigma_{\text{lin}}=1/(\rho_{\text{measured}}-\rho_S)$ fitted with the conductivity formula given by Eq. (26) (squares). For comparison, we give the theoretical conductivity curve (triangles) considering that the experiment had been done using HfO<sub>2</sub> as a dielectric. This allows one to compare the modification of the numerical values of  $\sigma$  due to a substrate change. [Data from Morozov *et al.* (2008), courtesy of Geim.]

can graphene be (Neugebauer *et al.*, 2009). Ultimately, the answer requires the identification of the limiting sources of electronic scattering in graphene (among those listed in Sec. III.A).

An approach combining Fermi's golden rule, Boltzmann equation, the Coulomb potential created by screened charged impurities, and a random phase approximation calculation of the dielectric function of graphene (Shung, 1986; Wunsch *et al.*, 2006) gave a first good account of the observed  $\sigma(\epsilon_F) \propto V_g$  behavior for graphene's conductivity (Adam *et al.*, 2007, 2008; Hwang and Das Sarma, 2008). When graphene was doped with potassium (Chen *et al.*, 2008), the measured conductivity agreed with the theory (Adam *et al.*, 2007), as expected. [We note that the conductivity of graphene covered by metal clusters is still far from being fully understood (Pi *et al.*, 2009).]

Using the same approach for a delta-function potential (Adam *et al.*, 2007, 2008; Hwang and Das Sarma, 2008), the prototype of a short-range scatterer, the computed conductivity is a constant number, independent of the gate voltage and of the dielectric constant of the medium. In what follows, we argue that this result is inconsistent. We note that an attempt to solve the Lippmann-Schwinger equation for a delta-function potential showed that this problem is ill defined (regularization of the problem is required in order to have a well-defined problem; as usual, this procedure introduces a length scale. This length scale is interpreted as the range of the short-range potential), and therefore the first Born approximation cannot be trusted. Indeed,

exact numerical calculations show that the first Born approximation is inadequate to describe the role of strong short-range scatterers in graphene (Klos and Zozoulenko, 2010). At the same time, a numerical calculation using the Kubo-Greenwood formalism (Nomura and MacDonald, 2007) showed that  $\sigma(\epsilon_F) \propto V_g$  for charged impurities (the level broadening due to scattering was however introduced by hand). The same work (Nomura and MacDonald, 2007) also showed that short-range impurities do produce a conductivity that depends on the gate voltage but in a sublinear manner. Also, previous calculations of  $\sigma(\epsilon_F)$  based on the SCBA showed that strong short-range scatterers, described by deltafunction potentials, do give rise to a gate-voltagedependent conductivity (Shon and Ando, 1998; Peres et al., 2006), a result embodied in Eq. (9). A similar conclusion was obtained from a semiclassical approach taking into account the chiral nature of massless Dirac fermions (Trushin and Schliemann, 2008).

The two different results-those based on Fermi's golden rule, as opposed to those obtained from the SCBA, for strong short-range potentials—are easily understood: the SCBA is a nonperturbative method, suitable for strong short-range potentials, which takes into account the large deviation of the wave function, within the potential range, from the usual plane wave used in the first Born approximation, as pointed out by Peierls (1979): indeed, the first Born approximation produces a large scattering cross section, whereas the exact calculation gives a small value. Since the conductivity depends on the scattering (transport) cross section, an incorrect determination of it will give, at least, an incorrect value for the impurity concentration in the material. Unfortunately, the reliance on the result based on Fermi's golden rule is widespread in the community and is being used to fit the experimental data (Hong et al., 2009), at the same time that the resonant scattering mechanism points toward the presence in the material of strong localized potentials (see Sec. III.A).

If it is certain that some amount of charged impurities is present at the silicon oxide-graphene interface (responsible for the electron and holes puddles), it is no less true that experiments do not rule out other sources of scattering. Indeed, recent experiments showed that both adsorbed hydrogen and vacancies led to conductivity curves indistinguishable in form from those of pristine graphene (Chen et al., 2009; Elias et al., 2009). The presence of these short-range scatterer (vacancies and hydrogen) is signaled by a significant Raman D-band intensity (Chen et al., 2009) since they couple electron states from the K and K' valleys (see Sec. V.B). By the same token, the presence in pristine graphene of such Dband would be the signature of the presence of shortrange scatterers in the material. Detailed Raman investigations in pristine graphene have been carried out (Ni et al., 2010), showing that, indeed, a small D peak is present in the Raman spectrum of the pristine material. Subsequent transport experiments (Ni et al., 2010) support strong short-range scatterers as the limiting source of scattering in graphene.

An experiment especially designed to address the importance of charged impurities used devices with dielectrics having high permittivity constants (Ponomarenko *et al.*, 2009). These experiments did not exclude completely the contribution of this type of impurities but did challenge the idea that charged impurities are the main source of scattering in graphene.

On the other hand, in another set of experiments, an apparently similar investigation was done, but with ice layers on top of graphene and reaching a different conclusion. It was argued that the results were consistent with charge scattering (Jang *et al.*, 2008). There is, however, at least one difficulty with the arguments developed in that work: the number of ice atomic layers was at the most six and therefore can hardly be considered an infinite dielectric made of ice; the lines of the electric field are essentially in the vacuum (Silvester and Ferrari, 1996; Sometani, 2000).

A number of questions can still be asked (Schedin *et al.*, 2007; Ponomarenko *et al.*, 2009; Monteverde *et al.*, 2010):

- (i) In a study of graphene's sensitivity to gases (Schedin *et al.*, 2007) (NO<sub>2</sub>,  $H_2O$ , and iodine acting as acceptors, whereas NH<sub>3</sub>, CO, and ethanol acting as donors), chemically induced charge-carriers concentrations as large as  $50 \times 10^{10} \text{ cm}^{-2}$  were achieved. The induced chemical doping shifted only the neutrality point of the conductivity curves, without any significant changes either in the shape of those curves or in the mobility of the devices; the estimated concentrations of added charged scattering centers was high as 10<sup>12</sup> cm<sup>-2</sup> (Schedin et al., 2007). Why is it that no appreciable changes in the mobility were measured in these experiments? [One possible way out can be envisioned: the chemical dopants may cluster, and this would reduce the effectiveness of their scattering effect (Katsnelson et al., 2009).] We also note that the definition of the mobility used in the analysis of the data (Schedin et al., 2007) has been criticized in the literature (Hwang and Das Sarma, 2007).
- (ii) In a study designed to test the prediction (Hwang and Das Sarma, 2008) of the charge scattering model for the ratio of the transport scattering time  $\tau$  and the elastic scattering time  $\tau_e$  for both monolayer and bilayer graphene, the experiments found disagreement between the predicted behavior and the measured data for both graphene systems. The measured deviations were found to be stronger for bilayer graphene (Monteverde *et al.*, 2010). Further, it was found that the measured data agree with the resonant scattering mechanism. How to reconcile this set of measurements with models explaining the mobility of both monolayer and bilayer graphene based on the charge scattering mechanism (Zhu et al., 2009)? We mention that the results of Monteverde *et al.* must be confronted with those of a similar experi-

ment (Hong *et al.*, 2009), reaching different conclusions.]

(iii) Since screening is strongly dependent on the value of the permittivity  $\epsilon$  of the surrounding medium, why is the mobility almost insensitive to changes of this parameter? For example,  $\epsilon$  for ethanol changes from 25 to 55 as the temperature drops from 300 K down to ~160 K, but an experiment done in ethanol showed no variation in graphene's mobility. We, however, note that in some experiments (Ponomarenko *et al.*, 2009) a certain amount of variation in the mobility was measured in some devices upon changing the dielectric constant. This result does show that charged impurities play some role as scattering centers but apparently not the limiting one.

The answers to the above questions remain debatable to some extent. The clarification of some of these issues could be taken to an ultimate test using a solid dielectric with a high relative permittivity. It just happens that strontium titanate (SrTiO<sub>3</sub>) has a relative permittivity of about 10 000 below T=50 K, which suddenly drops to 300 when the temperature rises above 50 K. A device using such a dielectric would produce a dramatic change in the mobility upon a drop in temperature below 50 K.

If we now refocus our attention on the role of strong short-range scatterers, we recall that both the linear and sublinear behaviors can be accommodated within a model based on what is now called scattering due to resonant scatterers, giving rise to midgap states (Stauber et al., 2007; Basko, 2008; Robinson et al., 2008; Wehling et al., 2009, 2010), plus the additional effect of charged impurities, which, however, do not play the central role. On the other hand, the simplest model based on shortrange scatterers, in which the effect of charged impurities is ignored, does not account for the observed dependence of the mobility on the dielectric constant of the device, which has been shown experimentally to be present to some extent (Ponomarenko et al., 2009). In Sec. **IV.B** we present the main results of such a simple model, and in Sec. IV.C we include the role of charged impurities, and an improved model taking into account both types of scatterers is given. This latter model is a simple combination of results already available in the literature, albeit presented with a different emphasis.

We stress that from the analysis of the SCBA results we see that features showing at energies close to the Dirac point are all proportional to  $\sqrt{n_i}$  (recall that  $n_i$  is the density of impurities per unit cell), as shown in Fig. 4. This introduces an energy scale  $\epsilon_{\min} \leq \hbar v_F \sqrt{n_i}/a_0$ , below which electron scattering based on plane waves breaks down, meaning that close to the Dirac point the results of Secs. IV.B and IV.C are expected not to hold.

Both models based on midgap states or on charged impurities, presented below, fail to give a satisfactory account of the physics close to the Dirac point since they are based on the scattering of plane waves.

Finally, in suspended graphene (Bolotin, Sikes, Hone, et al., 2008; Bolotin, Sikes, Jiang, et al., 2008; Du et al.,

2008), where the material is hanging over a trench, midgap states are expected to survive since some fraction of the corresponding scatterers will still be present, whereas charged impurities are expected to be absent. In the suspended situation, the mobility of the material will be limited only by resonant scatterers plus ripples induced by strain due to the electric field created by the gate (Fogler *et al.*, 2008; Bao *et al.*, 2009).

#### B. Partial-wave description of resonant scatterers

We assume the presence of short-range scatterers, which we model here as disks of radius R, and whose origin was discussed in Sec. III.B. The effect of the scatterers is such that the electron wave function is zero for r < R. The sizes of these disks are of the order of the size of the primitive lattice vectors. The circular shape takes the isotropy of the scattering process into a account, and the boundary condition allows a simple analytical solution. A vacancy is one of the possible physical realizations of the model just introduced.

The Dirac Hamiltonian (3) in polar coordinates r and  $\varphi$  reads (Hentschel and Guinea, 2007; Recher *et al.*, 2007; Peres, Rodrigues, *et al.*, 2009)

$$H_{\boldsymbol{K}} = -iv_F \hbar \begin{pmatrix} 0 & L_- \\ L_+ & 0 \end{pmatrix}, \tag{14}$$

with  $L_{\pm} = e^{\pm i\varphi}(\partial/\partial r \pm ir^{-1}\partial/\partial\varphi)$ . A particular solution of Eq. (14) with eigenvalue  $v_F \hbar k$  has the form  $\psi_m(rk) \propto (J_m(kr)e^{-im\varphi}, -iJ_{m+1}(kr)e^{-i(m+1)\varphi})^{\dagger}$ , where  $J_m(z)$  is the regular Bessel function of first kind and integer order *m*. This solution corresponds to a partial wave in the angular momentum representation of the plane wave. In the presence of the potential created by the disk we write the trial wave function as

$$\psi(rk) = A \begin{pmatrix} J_m(kr)e^{im\varphi} \\ iJ_{m+1}(kr)e^{i(m+1)\varphi} \end{pmatrix} + B \begin{pmatrix} Y_m(kr)e^{im\varphi} \\ iY_{m+1}(kr)e^{i(m+1)\varphi} \end{pmatrix},$$
(15)

where  $Y_m(z)$  is the irregular Bessel function of first kind and integer order *m*. We consider that at r=R the wave function satisfies the zigzag boundary conditions (Dominguez-Adamé, 1990; Akhmerov and Beenakker, 2008)  $\psi_{1,m}(kR)/\psi_{2,m}(kR)=0$ , where  $\psi_{i,m}(kr)$ , with i=1,2, is the *i* component of the Dirac spinor. This boundary condition makes sense since, as discussed in Sec. III.A, a resonant scatterer can effectively behave as a vacancy; in turn, a vacancy is a three-site zigzag edge. This boundary condition also represents the limiting case where the electronic probability flux is zero through the region where the potential is finite. The phase shift  $\delta_m(kR)$  of the *m* partial wave is given by (Hentschel and Guinea, 2007; Katsnelson and Novoselov, 2007; Stauber *et al.*, 2007; Basko, 2008; Wehling *et al.*, 2009)

$$\tan \delta_m(kR) = J_m(kR)/Y_m(kR). \tag{16}$$

The relative importance of the several phase shifts to the transport scattering cross section  $\sigma_T(kR)$  depends on the

value of  $k_F R$ . In 2D, the differential cross section  $\sigma(\varphi)$  reads  $\sigma(\varphi) = |f(\varphi)|^2$ , with  $f(\varphi)$  given by

$$f(\varphi) = \sqrt{\frac{2i}{\pi k}} \sum_{m=-\infty}^{\infty} e^{i\varphi m} e^{i\delta_m(k)} \sin[\delta_m(k)].$$
(17)

When  $k_F R < 1$ , the *s*-wave phase shift  $\delta_0(k_F R)$  is the dominant contribution. Making use of the relation  $1/\tau(k) = n_i v_F \sigma_T(kR) / A_c$  (Ziman, 1979), where  $\tau(k)$  is the transport relaxation time (see also Sec. V.A), and since the total transport cross section  $\sigma_T(kR)$  is obtained from

$$\sigma_T(kR) = \int_0^{2\pi} d\varphi \sigma(\varphi) (1 - \cos \varphi), \qquad (18)$$

the conductivity  $\sigma(k_F)$  is given by (both spin and valley degeneracies included)

$$\sigma(k_F) = e^2 v_F^2 \frac{\tau(k)}{A_c} \rho(\epsilon_F) = e^2 v_F \frac{\rho(\epsilon_F)}{n_i \sigma_T(k_F R)},$$
(19)

with  $\sigma_T(k_F R) = 4 \sin^2 \delta_0(k_F R)/k_F$ . Since we assume  $k_F R < 1$ , we also have  $1/\delta_0(k_F R) \approx 2 \ln(k_F R)/\pi$ , and the final result for the dc conductivity is then

$$\sigma(k_F) = g_0 \frac{3\sqrt{3}}{4\pi} \frac{a_0^2 \alpha V_g}{n_i} \ln^2(\sqrt{\alpha \pi V_g} R).$$
<sup>(20)</sup>

The result (20) for the conductivity holds as long as the Fermi momentum is larger than  $k_F \gtrsim \epsilon_{\min}/\hbar v_F$  (recall previous discussion). The conclusion is that resonant scatterers (strong short-range impurities), giving rise to midgap states, give a conductivity that is gate voltage dependent, with sublinear or quasilinear dependence on  $V_g$ , depending on the size of the scattering disk *R*. Furthermore, the conductivity [Eq. (20)] is not independent of  $V_g$  even if we take *R* to be of the order of the carbon-carbon distance,  $a_0$ .

In the first experimental study of the conductivity of suspended graphene (Du *et al.*, 2008), it was shown that this quantity is well described by fitting it to a model of midgap scattering states, that is, Eq. (20).

In Fig. 7, we fit the conductivity data of suspended and nonsuspended graphene using Eq. (20). In all cases a good fit is obtained, using impurity densities ranging from  $1.3 \times 10^{11}$  cm<sup>-2</sup> for nonsuspended samples down to  $0.7 \times 10^{10}$  cm<sup>-2</sup> for suspended ones. We note that for the devices termed K17 and K12 in Fig. 7 the  $n_i$  values used are  $n_i \simeq 0.8 \times 10^{11}$  and  $n_i \simeq 1.3 \times 10^{11}$  cm<sup>-2</sup>, respectively. The attempt to fit the same data with charged scatterers (Adam et al., 2007, 2008; Hwang and Das Sarma, 2008) gave concentrations of  $2.2 \times 10^{11}$  and  $4.0 \times 10^{11}$  cm<sup>-2</sup> for K17 and K12, respectively. The two sets of numbers for  $n_i$  have the same order of magnitude, but Eq. (20) gives a better fit to the data, except for the measurements shown in the top left panel of Fig. 7. For this particular device, made of suspended graphene, the maximum of the measured conductivity is about two times smaller than that measured in the other suspended device, whose data are shown in the top right panel of Fig. 7, suggesting that additional sources of disorder may have

been introduced during the fabrication process. We stress that the fits done in Fig. 7 use the density of impurities as the only fitting parameter since R has to be of the order of  $a_0$  (Wehling *et al.*, 2010); changes of order one in the value of R give small changes for the impurity concentration.

Some phenomenological approaches (Morozov et al., 2008) have tried to reconcile the measured sublinear behavior of the conductivity of graphene with the linear behavior (upon  $V_g$ ) predicted by the charge scatterers model. In the case of the data given in the right panel of Fig. 7, a sublinear behavior of the conductivity upon  $V_{g}$ (for graphene on top of  $SiO_2$ ) is evident. A linear behavior could be recovered by defining the measured resistivity  $\rho_{\text{measured}}$  as a sum of two terms  $\rho_{\text{measured}} \equiv \rho_g + \rho_S$ , where  $\rho_S$  is a fitting parameter. The conductivity  $\sigma_{sub}$ =1/ $\rho_{\text{measured}}$  is sublinear in  $V_g$ , whereas the conductivity  $\sigma_{\rm lin} = 1/(\rho_{\rm measured} - \rho_S)$  shows linear behavior. The fitting parameter  $\rho_S$  was assumed to be independent of  $V_{\alpha}$  and was attributed to short-range scatterers. The discussion presented above for strong short-range scatterers showed that this type of disorder does produce sublinear behavior of the conductivity upon  $V_g$ , even in the case  $R \sim a_0$ , with the same order of magnitude for impurity concentration as those proposed by the charge scattering mechanism (Adam et al., 2007, 2008; Hwang and Das Sarma, 2008). It is obvious then that, using the curves calculated with the midgap state mechanism, it is still possible to obtain a linear dependence of the conductivity on  $V_g$  by assuming a  $\rho_S$  fitting parameter as done in the phenomenological approach (Morozov et al., 2008). From the discussion in this section it is fair to say that the origin of  $\rho_S$  still needs clarification. Moreover, we can even ask the question whether the parameter  $\rho_S$  is really needed for the interpretation of the data.

Finally, we note that in our calculation we have not included the effect of intervalley scattering, which is known to be present when the scatterers are short range. If that effect is included, a contribution to the conductivity of the form given by Eq. (20) is found, albeit with a different numerical prefactor (Ostrovsky *et al.*, 2006).

#### C. Partial-wave description of Coulomb scatterers

We now derive the contribution to the conductivity of graphene due to Coulomb scatterers. We can think of three alternative scenarios for the origin of Coulomb scatterers: either they exist independently of the resonant scatterers or the latter can themselves be charged, carrying a fraction of the unit charge, or both cases can coexist. Experiments aiming at studying in detail the Raman D peak of pristine graphene can also shed light on this aspect by studying suspended pristine graphene before and after annealing.

The solution of the Dirac equation in 2D for the Coulomb potential was obtained more than ten years ago (Lin, 1999) for the subcritical regime (see below), and rediscovered in the context of graphene by different groups (Novikov, 2007a, 2007b; Pereira *et al.*, 2007; Shytov *et al.*, 2007), who also solved the case of the supercritical regime.

It was known for some time (Lin, 1997) that the Coulomb problem in the 2D Schrödinger equation provides a total cross section which does not coincide with the first Born approximation. The same happens with the 2D Dirac equation (Lin, 1999; Novikov, 2007a; Pereira *et al.*, 2007; Shytov *et al.*, 2007). The discussion given above restrains us from accepting results based on the first Born approximation without a critical analysis.

For the Coulomb problem, the Hamiltonian has the form  $H=H_K+IZe^2/4\pi\epsilon_0 r$  (*I* a 2×2 identity matrix) and the solution is sought in the form

$$\psi_{j}(\mathbf{r}) = \frac{1}{\sqrt{r}} \begin{pmatrix} f_{j}(rk)e^{i\varphi(j-1/2)} \\ \pm ig_{j}(rk)e^{i\varphi(j+1/2)} \end{pmatrix},$$
(21)

with j a half-integer number. When the trial wave function (21) is inserted into the Dirac equation, we get

$$\begin{bmatrix} \epsilon + \frac{g}{r} & \frac{-\partial_r - j}{r} \\ \frac{\partial_r - j}{r} & \epsilon + \frac{g}{r} \end{bmatrix} \begin{bmatrix} f_j \\ \pm i g_j \end{bmatrix} = 0, \qquad (22)$$

where j=m-1/2,  $\epsilon = E/v_F \hbar$ , *E* is the energy,  $g=Z\alpha_g$ , and  $\alpha_g = e^2/4\pi\epsilon_0 v_F \hbar \approx 2.2$  is graphene's fine-structure constant. The solution to Eq. (22) has been obtained by several, and the central quantity is the phase shift of the *j* partial wave, as in the case of Sec. IV.B. For this problem the phase shifts read

$$e^{2i\delta_j(g)} = \frac{j\Gamma(s-ig)}{\Gamma(s+1+ig)}e^{i\pi(j-s)},$$
(23)

with the property  $\delta_j(g) = \delta_{-j}(g)$ ,  $s = \sqrt{j^2 - g^2}$ , and  $\Gamma(x)$  the usual gamma function; the subcritical regime is defined by the condition g < 1/2. Contrary to the short-range scatterer problem, solved in Sec. IV.B, the phase shifts [Eq. (23)] do not depend on the energy of the incoming particle, but they do depend on the sign of the Coulomb potential and on which type of particle, an electron or a hole, is being scattered. The independence of  $\delta_i(g)$  on the energy is simple to understand from a straightforward argument based on dimensional analysis: on the one hand, the Coulomb potential has no intrinsic length scale, and on the other hand, the particle's mass is null. These two facts show that the problem as a whole has no intrinsic length scale (some sort of Bohr's radius, as in the nonrelativistic theory of the hydrogen atom) and therefore dimensionless numbers involving the momentum k cannot be formed, leading to the conclusion that the dimension of the cross section (dimension of length, in 2D) can only come from the momentum itself. That is, we are then bound to have  $\sigma_T(k) \propto 1/k$ , which gives the linear dependence on the gate voltage. The electronhole asymmetry of the cross section can partially account for the measured asymmetry of the conductivity curves. Another source of electron-hole asymmetry of the conductivity is originated in the metal contacts of the transistor (Huard et al., 2008).

TABLE I. Dependence of  $\Lambda(g)$  on the type of dielectric for both electrons, g > 0, and holes, g < 0. The impurities are assumed to have valence Z=-e. For ethanol, the dielectric function depends on temperature, as indicated between braces. Since graphene is in the ultrarelativistic limit, the value for  $\Lambda(g)$  cannot be obtained from adding only few partial waves.

Dielectric	$\epsilon_d$	$\alpha_g^{\text{effct.}}$	$\Lambda(g)$	$\Lambda(-g)$
H <sub>2</sub> O	80	0.05	0.013	0.012
Ethanol (160 K)	55	0.07	0.027	0.022
Ethanol (300 K)	25	0.13	0.10	0.07
HfO <sub>2</sub>	25	0.13	0.10	0.07
SiO <sub>2</sub>	4	0.37	1.20	0.46

The above solution assumes that graphene is floating in vacuum. In a real experiment, graphene is on top of a dielectric,  $SiO_2$  being the most common. Other dielectrics have also been used (Ponomarenko *et al.*, 2009). In these experimental conditions, the value of g is different from that given above.

In the case Z=1 and for graphene on top of a dielectric, a charge e in between the dielectric (with relative permittivity  $\epsilon_d$ ) and graphene behaves effectively as a charge with a value (Slater and Frank, 1969; Landau *et al.*, 1984) of  $e_r=2e/(1+\epsilon_d)$ . Additionally, the relative permittivity of graphene due to electron-electron interactions is renormalized to  $\epsilon_r=1+2\pi\alpha_g/[2(1+\epsilon_d)]$  (Shung, 1986; González *et al.*, 1999; Adam *et al.*, 2007). These two effects combined give an effective fine-structure constant for graphene of

$$\alpha_g^{\text{eff}} = \frac{\alpha_g}{\epsilon_r} \frac{2}{1 + \epsilon_d}.$$
(24)

Using the same procedure of Sec. IV.B, the conductivity of graphene due to Coulomb scatterers reads

$$\sigma = e^2 v_F \frac{k_F \rho(\epsilon_F)}{2n_i \Lambda(g)} = g_0 \frac{3\sqrt{3}a_0^2}{8n_i \Lambda(g)} \pi \alpha V_g, \qquad (25)$$

where  $\Lambda(g) = \sum_{m=-\infty}^{\infty} \sin^2(\delta_{m+1/2} - \delta_{m-1/2})$ . It is worth stressing that  $\Lambda(g)$  is different for particles, g > 0, and holes, g < 0, a behavior not captured by the first Born approximation (Adam *et al.*, 2007). In Table I we give the numerical values for the quantity  $\Lambda(g)$ , considering graphene on top of or submerged in different dielectrics.

We have now developed all the tools needed to perform the analysis of the data of Fig. 8. We start by fitting the data using the two models presented above separately, that is, Eqs. (20) and (25). We must stress that each of these two models have only one fitting parameter: the concentration of impurities (in the model for resonant scattering, the parameter *R* is fixed by the size of the primitive cell). In the right panel of Fig. 8 we plot the data  $\sigma_{sub}=1/\rho_{measured}$  and  $\sigma_{lin}=1/(\rho_{measured}-\rho_S)$  using the raw data  $\rho_{measured}$  (given in the left top panel of the same figure). In the case of  $\sigma_{sub}$ , the data can be fitted using Eq. (20) for midgap states. A perfect fit to both negative and positive gate voltages is not possible since



FIG. 9. (Color online) The conductivity data  $\sigma_{sub}=1/\rho_{measured}$ , also plotted in Fig. 8, but fitted using Eq. (27), which combines the effect of resonant and charged scatterers. In the legend,  $n_{short}$  and  $n_{Coloumb}$  refer to the concentration of resonant and charged scatterers, respectively. The concentration of impurities is the only fitting parameter used in the theory. [Data from Morozov *et al.* (2008), courtesy of Geim.]

by construction the model developed in Sec. IV.B preserves electron-hole symmetry; an improvement which does not preserve electron-hole symmetry is easy to develop by considering a large finite value (as opposed to an infinite value) for the effective potential  $g_{eff}$  as discussed in Sec. III.A [see also Araujo and Peres (2006); Stauber, Peres, and Castro Neto (2008)]; we show below that charged scatterers can account for the loss of electron-hole symmetry of the conductivity curves as well.

In the case of the data computed as  $\sigma_{\rm lin}$ , we fit the positive gate voltage region with Eq. (25) for charged scatterers. Note that since  $\Lambda(g) \neq \Lambda(-g)$  the computed conductivity has no electron-hole symmetry, an effect seen in the experiments (Chen et al., 2008). Nevertheless, although Eq. (25) does break electron-hole symmetry, the magnitude of the computed effect is far too strong, and therefore Eq. (25) is not able to fit the data over the negative and positive range of  $V_{\rho}$ , by assuming a single concentration of charged scatterers. It is worth noting that the concentration of impurities used to fit  $\sigma_{\rm sub}$  and  $\sigma_{\rm lin}$  is essentially the same for both types of scatterers. In the left bottom panel of Fig. 8 we depict the conductivity values (triangles), had we performed the same experiment using  $HfO_2$  as a dielectric. To understand such a large change, we look at Table I, where we show that  $\Lambda(g)$  can be reduced by one order of magnitude (positive g) from  $SiO_2$  to  $HfO_2$ , leading to the large increase in the conductivity shown in Fig. 8.

We now take into account, in a single model, the effect of both strong short-range and charged scatterers. Computing the conductivity as  $\sigma_{sub}=1/\rho$ , such that (Matthiessen's rule)

$$\rho = 1/\sigma_{\text{short}} + 1/\sigma_{\text{Coulomb}},\tag{26}$$

and with  $\sigma_{\rm short}$  computed using Eq. (20) and  $\sigma_{\rm Coulomb}$  determined from Eq. (25), we can fit the data of Fig. 8 quite accurately, as shown in Fig. 9. In this figure, the concentration of impurities leading to midgap states used in the fit was  $n_{\rm short}=1.5\times10^{11}$  cm<sup>-2</sup> and that for

charged scatterers was  $n_{\text{Coulomb}} = 2.4 \times 10^{10} \text{ cm}^{-2}$ , about seven times smaller than  $n_{\text{short}}$  (these two concentrations are, essentially, the only two fitting parameters in the model). The combined contributions from resonant scatterers and charged impurities allow one to fit  $\sigma_{\text{sub}}$  over the whole  $V_g$  range, using a single value for the impurity concentrations.

In conclusion, we made a thorough analysis of the role of resonant scatterers (which give rise to midgap states) and charge scatterers in the conductivity of graphene and showed that a coherent picture emerges from a scattering analysis of the transport based on the exact calculation of the phase shifts of scattered chiral Dirac fermions, as opposed to a calculation based on the first Born approximation.

Finally, we note that fine tuning details coming from the dependence of the dielectric constant of graphene on the wave vector (the polarization contributions) were not included in our simple model, except for the important effect of the renormalization of the fine structure constant, which corresponds to the large wave number limit.

Experiments will decide which scenario regarding the limiting source of scattering in graphene actually prevails.

# **D.** Transport across a strained region: A way of generating a transport gap

The main limiting factor of all graphene properties, in what concerns its application to nanoelectronics, is, most likely, the lack of a true band gap, as opposed to the biased graphene bilayer (McCann, 2006; McCann and Falko, 2006; Castro *et al.*, 2007). This fact can, however, be overcome by creating a transport gap.

In nowadays nanotechnology, understanding the effect of strain on the properties of devices is an essential step toward the improvement of their performance. For example, characterizing how strain can improve the properties of silicon-based devices is a mainstream research topic (Hÿtch *et al.*, 2008). As stated in Sec. III.A, both ripples and wrinkles can act as scattering centers as they effectively create random strain in the material, leading to a modification of the hopping energy t. In what follows, we show that strain in graphene gives rise to a rich structure in the electronic and transport properties of the material.

Being a 2D flexible membrane (Booth *et al.*, 2008; Kim and Castro Neto, 2008), stretching (which in graphene can be as large as 20%, being reversible) and bending graphene in a controlled way is feasible (Ferralis *et al.*, 2008; Kim *et al.*, 2009; Mohiuddin *et al.*, 2009), with consequences to the electronic (Pereira *et al.*, 2009) and transport properties of the material (Fogler *et al.*, 2009; Guinea *et al.*, 2010). As we see below, strain can be modeled by a fictitious gauge field (de Juan *et al.*, 2007), which can then act as an effective magnetic field. In some circumstances, it was predicted that this effective magnetic field can have an intensity as high as 10 T



FIG. 10. (Color online) Scheme of a device made of strained graphene. The central region is the strained part. In the assumed model, the effect of strain is to modify the hopping connecting a given carbon atom to its three neighbors in such a way that two of the hoppings are equal. Shown is the momentum of the electrons in the leads and in the strained region.

(Guinea *et al.*, 2010), leading to a pseudomagnetic quantum Hall effect. The presence of such an odd quantum Hall effect can, in principle, be experimentally observed using scanning tunneling microscopy, which is a direct measure of the density of states, and, therefore, sensitive to the reorganization of the spectrum due to the presence of the gauge field. Such type of experiments have been performed (Levy *et al.*, 2010) and found straininduced pseudomagnetic fields greater than 300 T.

In the case of suspended graphene (Teague et al., 2009) there are two sources of strain. One is induced by the electric field produced by the gate, which pulls the graphene membrane downwards. The solution of the corresponding elasticity problem produces an effective model where the effective vector potential is constant (Fogler et al., 2008; Pereira and Castro Neto, 2009), precisely the model we discuss below. The other source of strain depends on the thermal properties of graphene. Graphene's thermal expansion coefficient is anomalously large and negative (Bao et al., 2009; Faugeras et al., 2010), a feature which can be exploited to induce 1D and 2D ripples (with a periodicity of about 300 nm) possibly leading to novel strain-based engineered graphene devices (Pereira and Castro Neto, 2009; Guinea et al., 2010).

Consider a graphene-based device where the central part of the material, of length L, is a graphene ribbon under strain, with armchair edges oriented along the x axis, as shown in Fig. 10. The strained part is then connected to two pristine leads. It is well understood that the effect of strain can be included in the Dirac Hamiltonian in the form of a fictitious gauge field (Castro Neto *et al.*, 2009; Guinea *et al.*, 2010). The emergence of the fictitious gauge field is simple to understand. We assume that the hopping along the armchair edge is modified relatively to its pristine value t as  $t \rightarrow t + \Delta t$  [a detailed study of how strain changes the value of the hopping was done using *ab initio* methods (Ribeiro *et al.*, 2009)]. This adds a term to the Hamiltonian [Eq. (1)] of the form

$$\Delta t \sum_{\boldsymbol{R}_n} \left( |A, \boldsymbol{R}_n\rangle \langle \boldsymbol{R}_n + a_0 \boldsymbol{u}_x, B| + \text{H.c.} \right).$$
(27)

Passing from the tight-binding description to the continuous model, the contribution from Eq. (27) has a finite value at a given point in space. Since Eq. (27) couples the sublattices A and B at the same point in space its contribution to the effective Hamiltonian [Eq. (3)] has the simple form (Castro Neto *et al.*, 2009)

$$\boldsymbol{A}(x,y)\boldsymbol{\sigma}_{y} = -\theta(x)\theta(L-x)\frac{\Delta t}{ev_{F}}\boldsymbol{u}_{y}\boldsymbol{\sigma}_{y}, \qquad (28)$$

implying that the Dirac Hamiltonian maintains its original form, but with p replaced  $p \rightarrow (p_x, p_y + eA_y)$ . Clearly, we have a new Hamiltonian where the electrons now couple to a fictitious vector potential A through the usual minimal coupling of electrons to an electromagnetic field.

The question now is (Pereira and Castro Neto, 2009): How are the transport properties of Dirac electrons changed when transversing a region of strained graphene? As usual, the answer to this question is obtained by computing the transmission of the device by matching the wave functions from the left and right leads to those of the central region, at the positions x=0 and x=L. From the matching conditions we compute the total scattering matrix of the system (Nazarov and Blanter, 2009), relating the incoming and outgoing waves. The scattering matrix S is obtained easily from the total transfer matrix  $T_s$  of the structure using the same formalism introduced in Sec. III.C. In this case, the transfer matrix is given by

$$T_{s} = \frac{1}{D} \begin{bmatrix} u & v \\ v^{*} & u^{*} \end{bmatrix} \begin{bmatrix} u^{*}e^{-iLq_{x}} & -ve^{-iLq_{x}} \\ -v^{*}e^{iLq_{x}} & ue^{iLq_{x}} \end{bmatrix},$$
(29)

where  $D=4\cos\theta\cos\tilde{\theta}, \ u=e^{-i\theta}+e^{i\tilde{\theta}}, \ v=e^{-i\theta}-e^{-i\tilde{\theta}}$ ,  $\tan\theta$  $=k_y/k_x$ , and  $\tan \tilde{\theta}=(k_y-\delta)/q_x$ , with  $k_y$ ,  $k_x$ , and  $q_x$  the transverse momentum, the longitudinal momentum in the leads, and the longitudinal momentum in the device, respectively, and  $\delta = \Delta t / v_F \hbar$ . Finally, the energy in the leads has the form  $\epsilon = \sqrt{k_x^2 + k_y^2}$ , and in the central region  $\epsilon = \sqrt{q_x^2 + (k_y - \delta)^2}$ . The last equation shows that the effect of strain is to shift the position of the Dirac point in the Brillouin zone, a crucial effect on the explanation of the following results. Equation (29) was derived for energies in the continuum (no bound states). However, a fundamental property of the scattering matrix (or the  $T_s$  matrix for this purpose) is that bound states can also be obtained from the form derived for the scattering states, by looking at the poles of the S matrix. Since the S matrix is obtained from the inverse of the  $T_s$  matrix, its elements contain a factor which is the inverse of the determinant of  $T_s$ . Additionally, the  $S_{11}$  element of the S matrix (in this problem the S matrix is a  $2 \times 2$  matrix, since we are working on the propagating mode base) gives the amplitude of transmission across the strained region, its value being

0.2

dimensionless energy

0.05

$$S_{11} = \frac{4\cos\theta\cos\theta}{\cos(Lq_x)(|u|^2 - |v|^2) - i\sin(Lq_x)(|u|^2 - |v|^2)}.$$
(30)

From Eq. (30), we see that there are energies of perfect transmission, when  $Lq_x = n\pi$ , with  $n = 1, 2, \dots$  On the other hand, considering the case  $k_v=0$ , corresponding to normal incidence on the boundary, we obtain for the transmission

$$T = |S_{11}|^2 = \frac{\epsilon^2 - \delta^2}{\epsilon^2 - \delta^2 \cos^2(Lq_x)},$$
(31)

which is a number smaller than 1, meaning there is no Klein tunneling through strained graphene. At resonances  $Lq_x = n\pi$ , the transmission [Eq. (31)] is 1, and for energies in the range  $\delta/2 < \epsilon < \delta$ , it decreases exponentially with L since  $q_x$  becomes imaginary. In general, for angles (between k and y axis) satisfying the condition  $\theta_f > \arccos(-1 + \delta/\epsilon)$  the transmission, as computed from Eq. (30), is shown to be strongly suppressed for large L, an effect termed transport gap formation (Pereira and Castro Neto, 2009). True energy gaps can also be created in graphene by choosing an appropriate geometry of strain (Guinea et al., 2010). The reason behind this transport gap mechanism is easy to understand given the discussion in Sec. II; in the strained region the electrons' wave functions are no longer eigenstates of the helicity operator h. Therefore, since the helicity is not a constant of motion in this problem, Klein tunneling is lost and

backscattering is allowed. As mentioned, the denominator of the  $S_{11}$  element of the S matrix is all that it is needed to look for bound states in this system. We can imagine two different types of bound states: those decaying exponentially in the leads, but propagating inside the strained region, and those decaying exponentially in the three regions. The latter states are edges states living at the boundaries between the leads and the strained region. Looking only at the poles of  $S_{11}$  we can find that both types of bound states exist (Pereira and Castro Neto, 2009). The richness of states in strained graphene is due to the breaking of the chiral symmetry. In Fig. 11 we have represented the energies at which the transmission is unity (called resonances), the energies of the bound states, and the energy of the edge or surface states. The different types of states are a result of the different shifts of the two Dirac cones over the Brillouin zone (Hasegawa et al., 2006; Montambaux et al., 2009), induced by the strain and governing the vector potential of Eq. (28); the two apexes are shift by  $\delta$  due to strain, as seen above.

It was shown that in the problem under study there are in total five types of states:

- (1) scattering states,
- (2) band states (states localized in the junction along the x direction) propagating along the y direction,
- (3) localized states at the boundary of the junction,



resonances

bound states

- (4) filtered states, that is, scattering states decaying exponentially inside the junction for certain values of the incoming angle  $\theta_{f}$ , and
- (5) states such that the transmission occurs via evanescent waves for any orientation of the incoming momentum-it is said that all states are filtered.

The regions in the energy versus  $k_v$  plane where these types of states are shown in the bottom panel of Fig. 11. In conclusion, the example discussed shows that there is plenty of room at the bottom of strained graphene for a whole new subfield of graphene research: that of strainbased transport engineering or straintronics.

# V. QUANTUM CORRECTIONS TO THE DRUDE CONDUCTIVITY

Before discussing the quantum corrections to the Drude conductivity, we introduce some key concepts on electronic transport. Consider first the elementary transport theory in a normal metal, where electrons have an effective mass  $m^*$ . The velocity of the electrons at the Fermi surface is given by  $v_F = \hbar k_F / m^*$ , where  $k_F$  is the Fermi wave number whose value depends on the density of electrons. Impurities in an otherwise perfect crystal occasionally deflect electrons from free propagation, leading to the appearance of a mean free path  $\ell$ —the mean distance to the next collision. Since the dominant contribution to transport comes from electrons having velocity  $v_F$ , we can introduce a phenomenological parameter, the relaxation time  $\tau$ , defined as  $\tau v_F = \ell$ ; the elementary theory of transport then shows that the electronic conductivity of the metal reads (Ziman, 1979) (no spin or valley degeneracies included):  $\sigma_0 = e^2 n \tau / m^*$ . This is a purely classical result, known as Drude's formula, and which assumes that, after each collision, the electron loses memory of its previous linear momentum state. The calculation of  $\tau$  is usually obtained from Fermi's golden rule. The above description makes sense when  $\ell \gg \lambda_F = 2\pi/k_F$  (Ziman, 1979). If we now repeat the same analysis for graphene, we obtain (Adam et al., 2007, 2008; Peres, Lopes dos Santos, and Stauber, 2007; Stauber *et al.*, 2007; Basko, 2008)  $\sigma_0 = 2e^2 \tau v_F k_F / h$ , where we have now included the contributions of both spin and valley degeneracies.

It is also possible to view the conductivity problem as a random walk. In this case, the conductivity is related to the diffusion constant *D* through Einstein's relation (Chakravarty and Schimd, 1986)  $\sigma_0 = e^2 D \rho(\epsilon_F)$  (here again no spin or valley degeneracies included), with  $\rho(\epsilon_F)$  the density of states per unit area, and the units of *D* are those of area per time, in any spatial dimension. The diffusion constant, for order of magnitude estimates, can be taken as  $D \sim v_F \ell$ .

#### A. Weak localization in a normal metal

Weak localization is a correction to the classical conductivity of a disordered metal due to quantum interference and originates in the quantum-mechanical superposition principle. Electrons propagating in metals are subjected to a number of scattering mechanisms that give rise to a number of characteristic times.

The relaxation time  $\tau$  due to elastic collisions with static impurities is assumed to be the smallest scattering time and describes a reversible process. Other scattering mechanisms are irreversible in nature and lead to either the loss of phase coherence or energy relaxation; for instance, those caused by electron-electron and electronphonon interactions (excluding interactions with magnetic impurities). Contrary to  $\tau$ , the phase relaxation (or dephasing) time  $\tau_{\omega}$  is temperature dependent and at low temperatures is mainly due to electron-electron interactions. In the presence of a magnetic field, a new time scale  $\tau_B$  appears, which is of the order of  $\tau_B$  $\sim \ell_B^2/D$ , by simple dimensional analysis arguments, and where  $\ell_B = \sqrt{\hbar}/eB$  is the magnetic length. We now proceed to the discussion of the quantum interference effects using an intuitive approach (Abrikosov, 1988; Beenakker and Houten, 1991) rather than a formal one, as seems appropriate in the context of this Colloquium.



FIG. 12. (Color online) Pictorial representation for two types of scattering processes, whose physical interpretation is given in the text. The presence a finite magnetic field is represented by the flux  $\Phi$  piercing the area defined by the two time reversed trajectories.

Imagine an electron traveling from position A to B, as shown in Fig. 12, and we denote by  $a_i e^{i\phi_i}$  the probability amplitude for the electron to travel from A to B, along trajectory *i*. Since there are many indistinguishable trajectories, the total probability of traveling from A to B is

$$P_I(A \to B) = \left| \sum_i a_i^{i\phi_i} \right|^2.$$
(32)

We now show that quantum interference effects are much more important for what we call trajectories of type II, in Fig. 12, in which the initial and final points coincide (A=B).

For type I trajectories  $(A \neq B)$ , we have

$$P_{I}(A \to B) = \sum_{i} |a_{i}|^{2} + \sum_{i \neq j} a_{i}a_{j}e^{-i(\phi_{i} - \phi_{j})}.$$
(33)

Since the phases for different trajectories of type I are uncorrelated, we assume that the second term averages to zero, leaving us with the classical result, in which the probability to go from A to B is just the sum of the probabilities over all possible trajectories, that is,

$$P_I(A \to B) = \sum_i |a_i|^2 = P_I^{(cl)}(A \to B).$$
 (34)

However, for trajectories of type II (the same initial and final points), in the presence of time reversal symmetry, the situation is quite different. In fact, time reversed trajectories (going round the loop in clockwise and anticlockwise fashion), contribute to the sum of Eq. (33) with the same amplitude, in both modulus and *phase*. As a result, in the interference term,

$$\sum_{i\neq j} a_i a_j e^{-i(\phi_i - \phi_j)},\tag{35}$$

when i and j denote time reversed trajectories, the phases cancel, even before any averaging; this term gives a contribution exactly equal to the first one, since for every trajectory there is a time reversed pair. This then amounts to a probability

$$P_{II}(A \to A) = 2\sum_{i} |a_i|^2 = 2P_I^{(cl)}(A \to A).$$
 (36)

This effect of quantum interference therefore enhances the probability of return, relative to the classical result, decreasing diffusion and, therefore, the conductivity (Abrikosov, 1988; Beenakker and Houten, 1991); in other words, we have

$$\sigma_{wl} - \sigma_0 < 0, \tag{37}$$

where  $\sigma_{wl}$  stands for the conductivity of the metal considering the enhanced backscattering effect, due to quantum interference. It is the reduction in  $\sigma_{wl}$  relatively to  $\sigma_0$  that is known as weak localization.

In the presence of a magnetic field **B** the relative phase of the electron's wave function, associated with the two time reversed trajectories of type II, has the value  $\delta\phi = \pi\Phi/\phi_0$  as given by the Aharanov-Bohm effect, where  $\Phi$  is the magnetic flux piercing the area defined by the closed trajectory. Therefore, applying a magnetic field to the system suppresses the interference effect (because it changes the relative phase to a nonzero value) given by Eq. (36), and the low-temperature conductivity of the metal increases when the field is turned on; or, in other words, we have

$$\frac{\delta\sigma(B)}{\sigma_{wl}} \equiv \frac{\sigma_{wl}(B) - \sigma_{wl}}{\sigma_{wl}} > 0.$$
(38)

Using Eq. (38) we obtain experimental evidence of weak localization effects in the conductivity of a disordered metal.

If the spin-orbit interaction (Hikami *et al.*, 1980) can be ignored and there are no magnetic impurities in the metal, the times  $\tau$ ,  $\tau_{\varphi}$ , and  $\tau_B$  are the only relevant time scales, and they control the behavior of the lowtemperature conductivity.

We now extend the previous analysis to graphene. Again, as expected, the chiral nature of the electrons (or, equivalently, their nontrivial Berry's phase) will play a major role. As before, we keep the discussion as elementary as possible.

#### B. Weak localization in graphene

In graphene, the quasiexact conservation of the chirality and the existence of two valleys have profound effects in the low-temperature conductivity of the material. Below we present the general picture of the quantum corrections in graphene, referring the interested reader to the literature for the subtleties appearing under a detailed analysis of this problem (Suzuura and Ando, 2002; Aleiner and Efetov, 2006; McCann *et al.*, 2006; Morpurgo and Guinea, 2006; Mucciolo and Lewenkopf, 2010).

As shown in Sec. V.A, in a normal metal the only elastic time is the relaxation time  $\tau$ . In graphene the situation is more complex. In order to understand the complexity of the situation, consider two different matrix elements of a potential created by a given impurity. We assume the potential to have the form

$$V(\mathbf{r}) = \frac{u}{r_0^2 \pi} e^{-r^2/r_0^2}.$$
(39)

The range of the potential depends on the value of  $r_0$ : the larger  $r_0$ , the larger the range. The effect of this potential on the electrons within the same valley (denoted intravalley scattering) is given by the matrix element

$$\langle \psi_{+}(\mathbf{k}') | V(\mathbf{r}) | \psi_{+}(\mathbf{k}) \rangle = \frac{u}{8A_{c}} f(\mathbf{k}, \mathbf{k}') e^{-q^{2} r_{0}^{2}/4},$$
 (40)

with  $f(\mathbf{k}, \mathbf{k}') = \cos[\theta(\mathbf{k})/2 - \theta(\mathbf{k}')/2]$  and  $q = |\mathbf{k} - \mathbf{k}'|$ . If we take  $\epsilon_F = 0.5$  eV one obtains  $q \sim 0.2/a$ , with  $a = \sqrt{3}a_0$ . The function  $f(\mathbf{k}, \mathbf{k}')$  shows that the scattering is not isotropic in momentum space, a consequence of the chiral nature of electrons in graphene. From  $f(\mathbf{k}, \mathbf{k}')$ , we also see that the scattering amplitude for backscattering,  $f(\mathbf{k}, -\mathbf{k})$ , is zero, the fingerprint of Klein tunneling (recall Fig. 3) for massless Dirac electrons (Beenakker, 2008).

If the potential also couples electronic momentum states from K and K' valleys (denoted intervalley scattering) the matrix element, using wave functions from different valleys, reads

$$\langle \psi_{+}(\mathbf{k}')|V(\mathbf{r})|\psi_{+}(\mathbf{k})\rangle = \frac{u}{8A_{c}}g(\mathbf{k},\mathbf{k}')e^{-Q^{2}r_{0}^{2}/4},$$
 (41)

with  $g(\mathbf{k}, \mathbf{k}') = i \sin[\theta(\mathbf{k})/2 - \theta(\mathbf{k}')/2]$  and  $Q \simeq |\mathbf{K} - \mathbf{K}'| = 4\pi/(3a)$ . In this case, backscattering is permitted,  $g(\mathbf{k}, -\mathbf{k}) \neq 0$ , since scattering couples states in the  $\mathbf{K}$  and  $\mathbf{K}'$  valleys, which have opposite chirality (recall Fig. 3).

Equation (41) shows that only for very short-range potentials,  $r_0 \leq a$ , does intervalley scattering have a significant amplitude. For long-range potentials, only intravalley scattering plays a role.

From the above discussion it follows that, in the case of graphene, we need to define several elastic scattering times (Aleiner and Efetov, 2006; McCann *et al.*, 2006; Morpurgo and Guinea, 2006):

- τ<sub>iv</sub>, representing intervalley scattering, whose scatterers are very short-range potentials with range r<sub>0</sub> ≤ a, such as some types of adatoms, adsorbed hydrocarbons, or vacancies.
- (2)  $\tau_s$ , representing intravalley scattering, whose scatterers are long-range potentials, such as ripples, dislocations, and charged scatterers.
- (3)  $\tau_w$ , representing also another contribution to intravalley scattering. This scattering time has its origin in the fact that chirality is not an exact symmetry of Dirac fermions in graphene (due to trigonal warping effects), therefore allowing for some amount of backscattering within the same valley. The importance of this scattering time grows as the Fermi energy increases.

As long as the scattering potentials are long range, intervalley scattering is negligible and backscattering in graphene is absent, except from a small contribution from  $\tau_w$ . The effect just described is, at the more fundamental level, a consequence of the Berry's phase (of  $\pi$ ) acquired by massless Dirac electrons when they perform a closed chiral orbit (Berry and Mondragon, 1987; Mikitik and Sharlai, 1999). The Berry's phase transforms the constructive interference, we described above for normal metals, into a destructive one, leading to weak antilocalization. Under these circumstances, the interference effect seen in Sec. V.A for a normal metal cannot



FIG. 13. (Color online) The quantity  $\delta\sigma(B)$  is defined as in Eq. (38). Left: Weak antilocalization behavior (the gate voltage used was  $V_g \leq 1$  V, corresponding to an electron density  $n \leq 7 \times 10^{10}$  cm<sup>-2</sup>). Center: Weak localization behavior (the gate voltage used was  $V_g = 11$  V, corresponding to an electron density  $n \approx 8 \times 10^{11}$  cm<sup>-2</sup>). Right: Dependence of  $\delta\sigma(B)$  on the electronic density (it grows from I to III) at T=27 K. A fit of the data must use the rigorous formula derived in the literature (Aleiner and Efetov, 2006; McCann *et al.*, 2006). [Data from Tikhonenko *et al.* (2008, 2009).]

exist in graphene, forward scattering is enhanced and one should expect weak antilocalization effects to manifest themselves, that is, if  $\tau_{iv} \ge \tau_{\varphi}$  we have (ignoring  $\tau_w$ ) (McCann *et al.*, 2006; Suzuura and Ando, 2002)

$$\sigma_{awl} - \sigma_0 > 0, \tag{42}$$

where  $\sigma_{awl}$  represents the enhancement (antilocalizing effect) of the conductivity over Drude's result  $\sigma_0$  due to Klein tunneling. If short-range scatterers are present, then intervalley scattering plays a role, and since electrons in the K and K' valleys have opposite chirality, backscattering is present [see the function  $g(\mathbf{k}, \mathbf{k}')$ ], and we expect weak localization effects, according to Eq. (37); detailed calculations confirmed this picture (Suzuura and Ando, 2002; McCann et al., 2006). When the effect of a magnetic field is included, the general rigorous expression for the weak localization corrections was derived by two groups independently (Aleiner and Efetov, 2006; McCann *et al.*, 2006) and  $\delta\sigma(B)$  can be either positive or negative depending on the relative values of the different scattering times, including  $\tau_B$ . For a comprehensive discussion of the interplay between the different scattering times and the quantum corrections to the conductivity, the interested reader is referred to the technical literature (Aleiner and Efetov, 2006; McCann et al., 2006; Kechedzhi et al., 2007).

In the left panel of Fig. 13 we show, for small values of the magnetic field, a weak localization dip  $[\delta\sigma(B)$  grows] followed by, above a certain field value  $B^*$ , weak antilocalization behavior of the conductivity, since  $\delta\sigma(B)$ starts to decrease upon increasing the magnetic field over  $B^*$  [no saturation of  $\delta\sigma(B)$  is measured upon increasing B, as in the weak localization case]. In the central panel of Fig. 13, we show weak localization behavior in graphene since the corrections  $\delta\sigma(B)$  never decrease upon increasing the magnetic field and tend to saturation. Since the electronic density in the central panel of Fig. 13 is a few times larger than that in the left one, it seems that the effect of short-range scatterers is more effective at higher densities (Tikhonenko et al., 2009); at lower densities long-range scatterers dominate. Indeed, in the right panel of Fig. 13, we clearly see a crossover from weak antilocalization to weak localization as the electronic density increases from I to III, at a temperature of 27 K; considering important screening effects of charged impurities at large electronic densities, such a result sounds reasonable. It is a remarkable experimental fact that quantum interference effects just discussed can be observed in graphene at temperatures as high as ~200 K (Tikhonenko et al., 2009).

As stated, we expect that in graphene the presence of different kinds of defects (in different concentrations) will control whether weak localization or weak antilocalization is observed. This depends on the relative value of the different elastic times introduced above and on the electron density. A detailed analysis of this point is essential for a correct interpretation of the data, and has been done in great detail (McCann *et al.*, 2006; Morpurgo and Guinea, 2006). The numerical values for the different scattering times can be obtained from the experimental data (Tikhonenko *et al.*, 2008).

Finally, we note that the observation of quantum corrections to the conductivity in graphene seems to depend on the details of the fabrication process, which determines the amount of rippling introduced in the system (Morozov *et al.*, 2006). Routes for suppression of weak (anti)localization effects have been considered (Khveshchenko, 2006) and this effect was experimentally observed as well (Morozov *et al.*, 2006; Tikhonenko *et al.*, 2008). As in the case of strain discussed in Sec. IV.D, ripples are equivalent to effective gauge fields which break time reversal, leading to the suppression of weak localization effects, within each valley. In the system as a whole (both valleys considered) the full time reversal symmetry is preserved.

### VI. THE OPTICAL CONDUCTIVITY OF GRAPHENE IN THE INFRARED TO VISIBLE RANGE OF THE SPECTRUM

In the ensuing sections we discuss the calculation of the percentage of light transmitted by a graphene membrane when light shines from behind. This property is controlled by the optical conductivity  $\sigma(\omega)$  of the material. We analyze how and why the experimental behavior of  $\sigma(\omega)$  deviates from the predictions of the independent electron model.

#### A. Graphene as a transparent membrane

The calculation of light absorption by a given material is equivalent to the calculation of the optical conductivity. In general, such a calculation proceeds using Kubo's formula. In the case of graphene, it is possible to use



FIG. 14. (Color online) Pictorial description of the optical excitation of electrons in graphene. The absorption of a photon can only induce vertical interband transitions. From left to right we have graphene doped with holes, neutral, and doped with electrons.

Fermi's golden rule to obtain directly the fraction of absorbed light, which turns out to be a much simpler calculation than computing the optical conductivity first (Kravets et al., 2010). The central quantity to be computed is the transition rate of electrons excited from the valence band to the conduction one, as shown in Fig. 14.

In the presence of a vector potential A the Dirac Hamiltonian has the form

$$H_{\boldsymbol{K}} = v_F \boldsymbol{\sigma} \cdot (\boldsymbol{p} + e\boldsymbol{A}). \tag{43}$$

We represent the electric field as  $E = -\partial A / \partial t$  and choose the polarization of the field along the x axis: A $=\hat{x}A_0(e^{i\omega t}+e^{-i\omega t})/2$ . The term  $v_F\boldsymbol{\sigma}\cdot\boldsymbol{e}\boldsymbol{A}$  will be taken as perturbation, and in the spirit of time dependent perturbation theory, only the exponential with negative exponent is taken. The transitions induced by light absorption are now controlled by the  $\sigma_x$  matrix. Clearly the matrix element  $\langle \psi_{\lambda} | \sigma_{\rm r} | \psi_{\lambda} \rangle$  cannot contribute to the conductivity since light cannot induce transitions within the same band, among states of equal momentum. The only nonvanishing contributing matrix element is therefore  $\langle \psi_1 | \sigma_x | \psi_{-1} \rangle = -(i/2) v_F e A_0 \sin \theta(\mathbf{k})$ . The transition rate is then given by Fermi's golden rule:

$$W_{1,-1}(\boldsymbol{k}) = \frac{2\pi}{4\hbar} v_F^2 e^2 A_0^2 \sin^2 \theta(\boldsymbol{k}) \,\delta(2v_F k\hbar - \omega\hbar). \tag{44}$$

The Dirac delta function in Eq. (44) enforces the condition that only electrons with energy  $\omega/2$  can be excited to the conduction band. The transitions we are referring to are shown in Fig. 14. To obtain the contribution from all states we have to integrate over the momentum and multiply the result by four (two for spin times two for valley). The calculations are elementary and the result for the total transition rate per unit area is

$$1/\tau = e^2 A_0^2 \omega / 8\hbar^2.$$
 (45)

If light of frequency  $\omega$  is shining upon a unit area of graphene, the amount of absorbed power per unit area is  $W_a = \hbar \omega / \tau$ . The energy flux impinging on graphene is given by  $W_i = c \epsilon_0 E_0^2/2$ , with  $E_0 = A_0 \omega$ . Therefore the fraction of transmitted light is (Nair et al., 2008)





FIG. 15. (Color online) An optical image of an aperture partially covered with graphene and its bilayer (from left to right: air/graphene/bilayer), taken in a light transmission experiment (courtesy of A. K. Geim).

$$T = 1 - W_a / W_i = 1 - \pi \alpha \simeq 0.977, \tag{46}$$

with  $\alpha = e^2/4\pi\epsilon_0\hbar c$  the fine structure constant. The absorption of light is therefore independent of frequency and given only by universal constants. The high transmittance of graphene is shown in Fig. 15; it is remarkable that a one atom thick membrane can be seen by the naked eve.

It follows from the previous analysis that the transmission at finite doping is given by

$$T(\epsilon_F) \approx (1 - \pi \alpha) \theta(\omega - 2\epsilon_F),$$
 (47)

where the Heaviside step function takes into account that absorption can only occur for frequencies larger than twice the Fermi energy, due to Pauli's principle. The result given by Eq. (46) is identical to the one given by a rigorous calculation based on Kubo's formula (Peres et al., 2006; Abergel et al., 2007; Gusynin et al., 2007; Kuzmenko et al., 2008; Peres and Stauber, 2008). The reason why the perturbative calculation works so well is because the final answer is controlled by the small dimensionless parameter  $\alpha$ . The reason why the transmission is controlled by the fine structure constant originates in the chiral nature of the electrons in graphene, a result extensible to few-layer graphene (Min and Mac-Donald, 2009).

It is now a simple matter to include corrections to the linear spectrum of graphene in the formalism (the conical nature of the spectrum is valid for energies of the order of  $\leq 1 \text{ eV}$ ). The addition of a next-nearestneighbor hopping term can also be included and treated within this formalism. The case of a next-nearestneighbor hopping is actually trivial, being proportional to the identity matrix its contribution is zero. In fact, it is proven in general (Stauber, Peres, and Geim, 2008) that the contribution of the next-nearest-neighbor hopping only enters in the final result as a renormalization of the energy spectrum.

As stated, the transmittance of light through graphene can be computed from previous knowledge of the optical conductivity of the material. The transmittance is calculated from the solution of Fresnel's equations, reading (Pedersen, 2003; Abergel *et al.*, 2007; Blake *et al.*, 2007; Stauber, Peres, and Geim, 2008)

$$T = |1 + \sigma(\omega)/(2c\epsilon_0)|^{-2}, \tag{48}$$

where  $\sigma(\omega)$  is the optical conductivity (Gusynin and Sharapov, 2005; Peres *et al.*, 2006; Falkovsky and Pershoguba, 2007; Falkovsky and Varlamov, 2007; Gusynin *et al.*, 2007, 2009; Stauber, Peres, and Geim, 2008) of graphene given at zero temperature and within the independent electron approximation by ( $\epsilon_F > 0$ )

$$\sigma(\omega) = \sigma_0 \theta(\omega\hbar - 2\epsilon_F) + i\sigma_0 \frac{4\epsilon_F}{\pi\omega\hbar} - i\frac{\sigma_0}{\pi} \ln \frac{|\hbar\omega + 2\epsilon_F|}{|\hbar\omega - 2\epsilon_F|}.$$
(49)

The quantity  $\sigma_0 = \pi e^2/(2h)$  is termed the ac universal conductivity of graphene. Inserting Eq. (49) into Eq. (48) and taking  $\epsilon_F = 0$  we obtain the result of Eq. (46). Working the other way around, using Eq. (46) in Eq. (48), we obtain for neutral graphene  $\sigma(\omega) = \sigma_0$ , in accordance with Eq. (49). The fact that for neutral graphene  $\sigma(\omega)$  is given in terms of universal constants only, with no reference to any of the material parameters, is a rare result in condensed matter physics. If the intensity of light impinging on graphene is *large*, then nonlinear corrections to *T* start to play a role which is expected to lead to an increase in the transmittance (Mishchenko, 2009; Rosenstein *et al.*, 2010). The nonlinear optical susceptibility coefficients of graphene have recently been measured using four-wave mixing (Hendry *et al.*, 2010).

Due to its high transmittance, graphene can be used as transparent conductive electrodes in solar cells and liquid crystal devices (LCDs) (Blake *et al.*, 2008; Wang *et al.*, 2008; Bae *et al.*, 2010).

#### B. The optical conductivity of neutral graphene

We now discuss the experimental results for the optical conductivity of neutral graphene and how those measurements deviate from the independent electron model presented above.

In Fig. 16 we show measurements from two different groups (Mak *et al.*, 2008; Nair *et al.*, 2008) in two different regions of the spectrum. For photon energies  $E_{\gamma}$  below 1.2 eV (in the near infrared region), the data were taken from reflectance measurements, at room temperature. The absorbance of the different samples is spectrally flat within a band of 10%. Roughly speaking, the transmittance follows the value given by Eq. (46). A more detailed analysis shows that the transmittance below  $E_{\gamma} < 0.5$  eV increases over the universal value, whereas closer to  $E_{\gamma} \lesssim 1.2$  eV it decreases slightly from that value. According to Mak *et al.* (2008), and for energies  $E_{\gamma} < 0.5$  eV, both temperature effects and some amount of variable extrinsic doping decrease the conductivity and therefore produce an increase in the transmit



FIG. 16. (Color online) Transmittance of graphene. For photon energies below 1.2 eV, we plot data from reflectance measurements taken by Mak *et al.* (2008); different curves correspond to different graphene devices (courtesy of Mak). For photon energies larger than 1.2 eV, we plot data from two different types of measurements (Nair *et al.*, 2008): narrow bandpass filters, with a full band width at half maximum of 10 nm, and standard spectroscopy measurements. The dashed line is the result of Eq. (47). The solid line, to the right of 1.2 eV, is a plot of *T* obtained from a calculation of the conductivity, including trigonal warping corrections (Stauber, Peres, and Geim, 2008).

mittance. In other words, if light absorption decreases, then the transmittance increases. This effect is equivalent to a finite chemical potential (having effectively a Pauli's principle based blocking effect), which contributes to an increase in the transmittance. The temperature effect that they (Mak et al., 2008) used in their argument was predicted to be of importance at room temperature and energies below 0.5 eV for undoped graphene (Peres and Stauber, 2008), in agreement with the experimental measurements. Additionally, this set of measurements showed that the optical conductivity of graphene can also be affected by unavoidable doping and intraband scattering. Indeed, a SCBA (Peres et al., 2006) calculation of the conductivity of graphene at zero temperature and zero doping showed that  $\sigma(\omega)$  departs from its universal value,  $\sigma_0 = \pi e^2/(2h)$ , being strongly reduced at low frequencies, due to disorder.

In conclusion, the deviation of the transmittance of graphene from the universal value predicted for Dirac fermions is a way of gaining insight on other electronic effects present in the material (Li, Henriksen, *et al.*, 2008).

Figure 16 also shows the transmittance of graphene in the photon energy range 1.2–3 eV. The measured value follows the prediction of Eq. (46), except at energies around 3 eV, where absorption increases. Since at energies as large as 3 eV the electronic energy dispersion deviates considerably from the Dirac cone approximation—an effect known as trigonal warping—a calculation taking into account trigonal warping corrections to the band structure of graphene was performed (Nair *et al.*, 2008; Stauber, Peres, and Geim, 2008), and the result is given by the solid line in Fig. 16. The calculation does predict an increase in light absorption at energies around 3 eV (an effect opposite to that discussed above for energies  $E_{\gamma} < 0.5$  eV) but falls short on accounting for the magnitude of the effect. Within the independent electron model, the computed enhancement of the conductivity is essentially due to the increase in the density of states as the Van Hove singularity is approached, which is located at the energy ~2.7 eV. Thus, transitions between states located at the Van Hove singularities of the valence and the conduction bands require photons of energy ~5.4 eV. Optical experiments using photons of about this energy have confirmed the strong enhancement of light absorption due to the Van Hove singularities (Geim, 2009).

Two possible additional causes for such an increase in the absorption come to mind: contamination of the sample due to some organic residues (originated from the exfoliation process) or/and many-body effects (Herbut *et al.*, 2008; Mishchenko, 2008). A recent calculation, however, showed that electron-electron interactions correct the transmission (reducing it) by only 0.03–0.04 % (Sheehy and Schmalian, 2007, 2009; Katsnelson, 2008). On the other hand, in the regime of energies relevant for the visible range of the spectrum, the fine structure constant of graphene  $\alpha_g$  is a number of order 1, a fact casting reasonable doubts on the validity of any perturbative calculation.

A recent ab initio calculation (Yang et al., 2009) used the Kohn-Sham eigenvalues and eigenvectors to compute the optical conductivity of graphene from infrared to visible frequencies. This type of mean-field calculation includes electron-electron interactions by means of the exchange and correlation approximations. The optical conductivity obtained does not fit exactly the data of Fig. 16 since it predicts an absorption higher than what is measured experimentally, in the full frequency range. Nevertheless, the proposed excitonic effects (included via the solution of the Bethe-Salpeter equation) were shown to account well for the experimental deviations (to lower energies) in the enhancement in light absorption for photon energies associated with transitions between states located at the Van Hove singularities of the valence and the conduction bands (Geim, 2009) relatively to the predictions made by the noninteracting electrons theory.

Indeed, the elementary theory predicts an intense absorption peak at about 5.2 eV, whereas the measured data show a red shift of the peak to 4.6 eV. The discrepancy can be solved by considering the mutual attraction of the electron-hole pair, created at the two Van Hove singularities, when a photon of the right frequency is absorbed.

The energy redshift mentioned is easy to understand from the point of view of the mutual attraction of the electron-hole pair (forming an exciton): since the electron and hole have opposite charges, the effective energy seen by the photon being absorbed is the noninteracting value minus a positive correction coming from the electrostatic attraction between the electron and the hole created by the absorption of the photon.

#### C. The optical conductivity of gated graphene

Measurements of the optical conductivity of gated graphene, in the far-infrared region of the spectrum (Li, Henriksen, *et al.*, 2008), also show strong deviations from the simple theory given above, and expressed in concise form by Eq. (49).

The deviations seen in the data (Li, Henriksen, *et al.*, 2008), for all values of the gate-voltage considered in the experiment (ranging from  $V_g=10$  to 71 V), are of five different types: (i) finite absorption below  $2\mu$ , which is due to both interband and intraband elastic and inelastic scattering processes; (ii) broadening of the absorption edge around the energy threshold  $2\mu$ ; (iii) an enhancement of the conductivity above the universal value  $\sigma_0$  in the energy range between  $2\mu$  and  $2\mu + E^*$ , where  $E^*$  is a characteristic energy scale; (iv) a reduction in the conductivity below  $\sigma_0$ , at energies above  $E^*$ , with the conductivity as a function of frequency having a positive curvature; and (v) the imaginary part of the conductivity is larger than the value predicted by the noninteracting model for energies  $\hbar\omega \ge 2\mu$ .

Additionally, we point out that the optical conductivity curves measured experimentally (Li, Henriksen, *et al.*, 2008) collapse on top of each other when replotted as a function of  $\omega/\mu$ , implying that the mechanism causing deviations from the noninteracting approximation must be intrinsic.

To explain the measured deviations, it is necessary to take into account disorder, temperature, electronic density inhomogeneities (Zhang et al., 2009), and electronelectron interaction effects of excitonic nature (Peres et al., 2010). In Fig. 17 we show one set of the measured data (solid curve) together with calculations using two models: (i) a model (dashed curve) where the independent electron theory is supplemented with the effect of disorder (computed with the two models discussed in Sec. IV.A) and (ii) a calculation including excitonic effects (dash-dotted curve) on top of model (i). It is clear that the first one, considering only disorder, does not account for the five deviations observed in the data, relatively to the independent electron model; it partially accounts for the enhancement of the conductivity below  $2\mu$ . The additional optical response observed in the data (in this frequency range) must come from intraband scattering processes (Grushin et al., 2009), not included in model (i). Points (ii)-(v) are all accounted for by including excitonic effects, that is, model (ii). There is, however, the need to use in the model a higher temperature, T=120 K, than that measured experimentally by the finger of the cryostat, T=54 K. This can be justified by recalling that graphene is a system presenting small inhomogeneities of the electronic density. This fact effectively smears the chemical potential and such an effect can be accounted for by considering an effective higher temperature, as was shown to be the case in the interpretation of the optical response of graphene's bilayer (Kuzmenko et al., 2009).

In the same set of measurements (Li, Henriksen, *et al.*, 2008), an increase in the Fermi velocity over the value



FIG. 17. (Color online) Optical conductivity of gated graphene on top of silicon oxide, in units of  $\sigma_0$ . The data are given by the curve. The dashed curve is a calculation taking disorder into account, and the dot-dashed curve is a calculation including disorder and electron-electron interactions. The experimental curves refer to a gate voltage of 28 V, which corresponds a Fermi energy of  $\mu \approx 0.18$  eV. The calculation took an effective temperature of 120 K. In the left (right) panel we have the real (imaginary) part of the conductivity. In the inset, the measured dc conductivity of the device (solid curve) depicted together with a fit of  $\sigma(\varepsilon_F)$  using Eqs. (20) and (25). The fit of the dc conductivity fixes the concentration of impurities to the values of  $n_i=2\times10^{11}$  cm<sup>-2</sup>, for resonant scatterers, and  $n_i=1$  $\times10^{11}$  cm<sup>-2</sup>, for charged ones (dashed curve). [Data from Li, Henriksen, *et al.* (2008), courtesy of Li.]

 $1.1 \times 10^6$  m/s was measured, upon diminishing the gate voltage. The renormalized Fermi velocity, due to exchange, was predicted to be (including the Thomas-Fermi screening of the Coulomb potential)

$$v_F = v_{\text{bare}} + \frac{e^2}{4\pi\epsilon_0\epsilon_d\hbar} \left( \ln \frac{2q_c}{9k_F} - \frac{1}{3} \right), \tag{50}$$

where  $v_{\text{bare}}$  is the bare Fermi velocity, and therefore not an observable parameter,  $q_c \sim 1 \text{ Å}^{-1}$  a cutoff momentum, and we have used the fact that the Thomas-Fermi screening momentum is for graphene on silicon oxide given by  $q_{\text{TF}} \approx 2k_F$  [we note that Eq. (50) is an extension, taking screening into account, of previous results (González *et al.*, 1996; Hwang *et al.*, 2007; Polini *et al.*, 2007)]. The result (50) does show that  $v_F$  increases upon decreasing  $k_F$ , but the formula fails to fit the data (Li, Henriksen, *et al.*, 2008) over the measured gate voltage range, especially for larger  $V_g$ . Alternatively, phonons also seem to partially account for the Fermi velocity renormalization seen in the experiments (Peres *et al.*, 2008; Stauber, Peres, and Castro Neto, 2008; Gusynin *et al.*, 2009).

The renormalization of the Fermi velocity suggests that contributions from many-body effects can be important, but an experiment with a higher degree of accuracy should be repeated since cyclotron mass measurements (Novoselov, Geim, *et al.*, 2005) do not see deviations of the Fermi velocity from  $v_F \approx 1.1 \times 10^6$  m/s upon varying the electronic density.

Finally, we note that, as in the case of neutral graphene discussed in Sec. IV.B, the electron-hole pair mutual-attraction also induces a shift in the Fermi edge at  $\omega = 2\mu$  toward lower energies (redshift effect), since, as before, it renormalizes the noninteracting energies by adding a negative number.

In conclusion, the optical response of graphene is a property of the material where different kinds of quantum effects seem to play an important role, all on equal footing. Exploring graphene for nanophotonic devices surely requires a detailed understanding of its optical properties.

#### **VII. CONCLUSIONS**

We have given an introductory review on the transport properties of graphene, touching the relevant aspects of this topic. A survey of the literature was given along with a discussion of elementary models, which, despite their simplicity, are in good quantitative agreement with many features of the data. Many of these models were discussed in greater detail in the literature (to which due credit is given) but using more formal methods. We hope that the topics discussed in this Colloquium may contribute to a wider dissemination of the physics of graphene among the nonspecialized audience.

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